

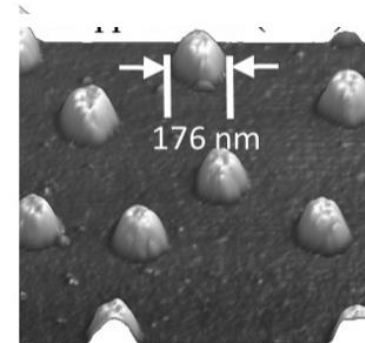
Nanostructures: from sensors to quantum tunneling devices ...

Edgar J. Patiño

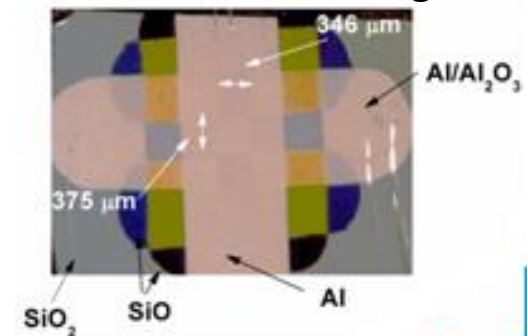
Universidad de los Andes (Physics)– Bogotá Colombia



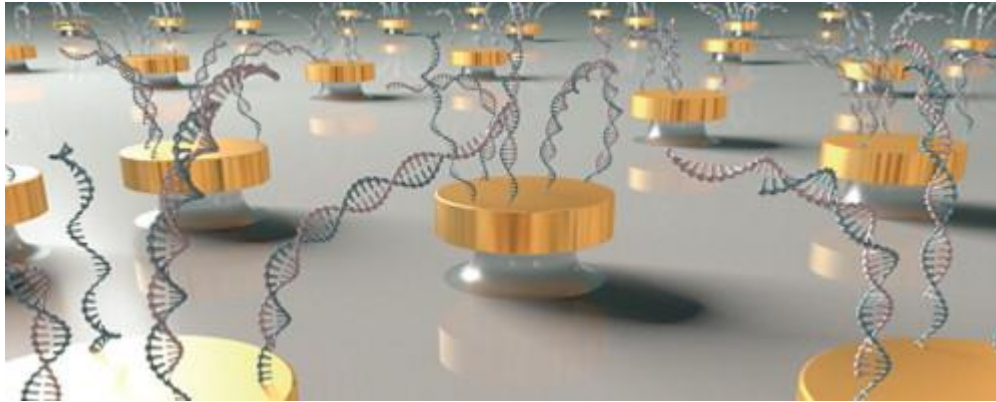
Plasmonic sensors



Quantum Tunneling



Plasmon resonances in nano structures



César Aurelio Herreño-Fierro (PhD student)

Edgar J. Patiño Zapata

Grupo de Física de la Materia Condensada

Departamento de Física

Universidad de los Andes

Alfonso Cebollada Navarro

Gaspar Armelles

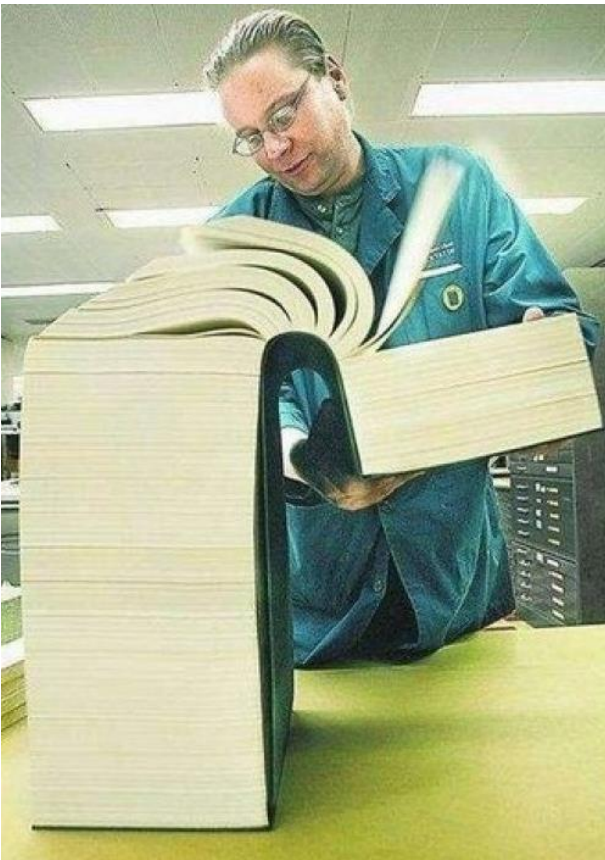
Grupo de Magnetoplasmonica

Instituto de Microelectrónica de Madrid –

Centro Nacional de Microelectrónica (CSIC)

- Motivation - > Why is it important why should we care about “plasmons” -> magnetic response?
- Plasmon resonance and Magnetic optic Kerr Effect (MOKE) as separate effects
- What happens with MOKE when plasmons are present? -> magneto plasmons TMOKE experiments
- Conclusions

Motivation



$\sim 125 \times 14000\text{-pages-books}$
 $\rightarrow 8Gb$



$\sim 125 \times 8Gb\text{-flash-memories}$

$\rightarrow 1\text{ second}$

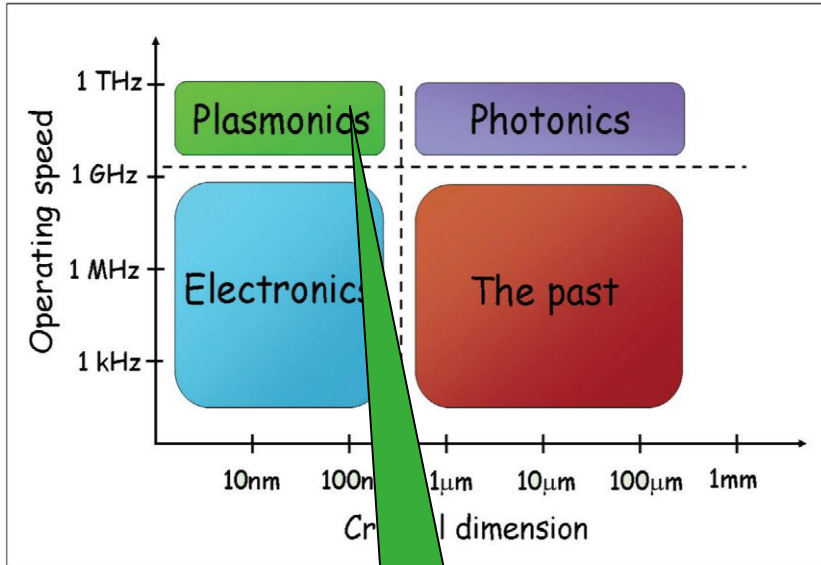


photonics - speed

14000 pages \rightarrow 70Mb

Speed vs Storage

Operation Speed



© Materials Today JULY-AUGUST 2006 | VOLUME 9 | NUMBER 7-8

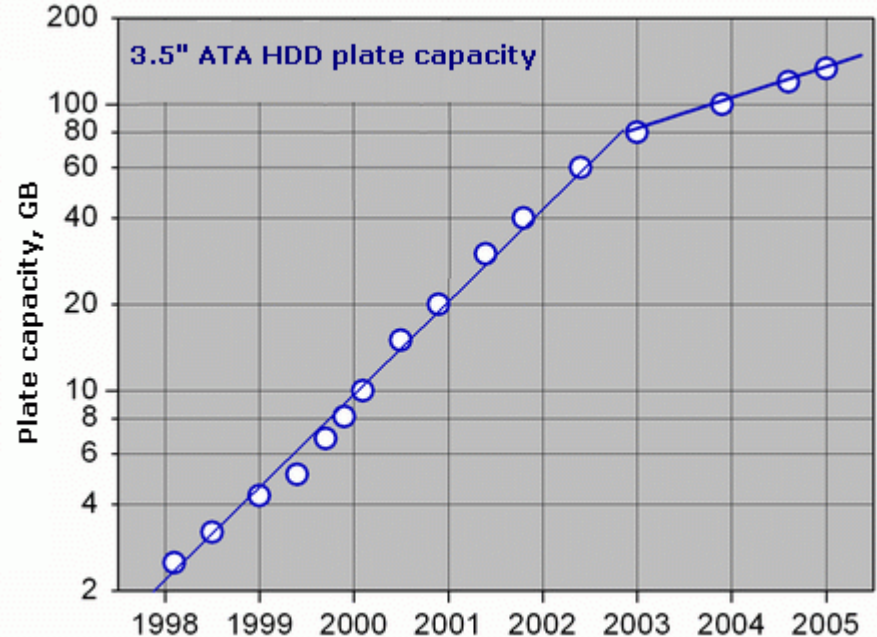
Passive
Devices

Active
Devices

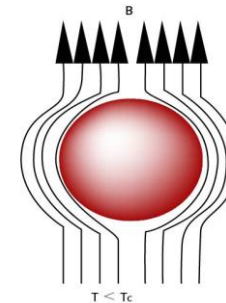
Wave guides,
resonators,
interferometers etc.

Switches, transistors,
detectors, logic gates
etc.

Crecimiento capacidad de los discos duros



<http://ixbtlabs.com/articles2/digests/hdd2k4.html>

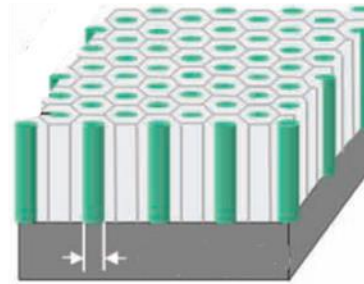


Magnetoplasmons

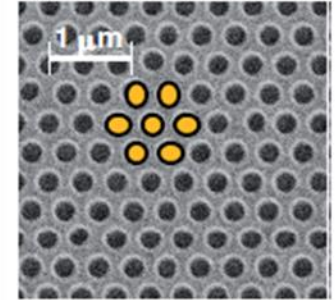
Multilayered [1]
(homogeneous)



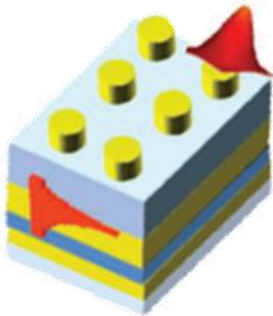
Embedded nanowires [2]



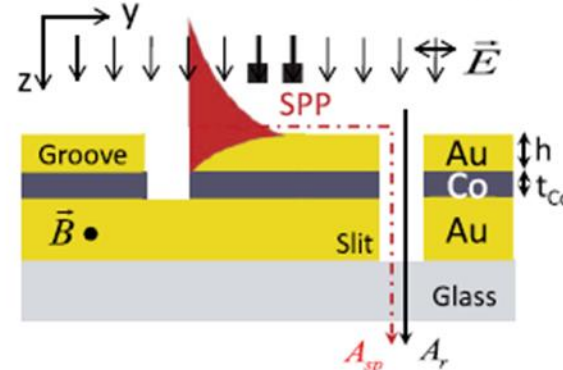
Perforated membrane [3]



Nanodisks [4]



SPP interferometer [5]



METAL
 +
FERROMAGNET

- [1] Phys. Rev. B. **64**, 235422 (2001)
- [2] Phys. Rev. B. **81**, 054424 (2010)
- [3] Phys. Status Solidi RRL **4**, No. 10, 271–273 (2010)
- [4] Optics Express, **18**, 15635 (2010)
- [5] Phys. Rev. B. **86**, 035118 (2012)
- [6] New J. Phys. **15** 075024 (2013)

Magnetoplasmonic materials

Interaction Between Light and Matter

Plasmons

What is a plasmon?



Colective oscillation of a gas of
electrons

-> quantum of “electron charge
oscillation” (**Plasmon**)

Lycurgus Cup – roman artisans 1600 years ago (IV century). Normally green under external light turns red when illuminated from within. This is the result of plasmon excitation within the glass matrix (nano particles of gold an silver)

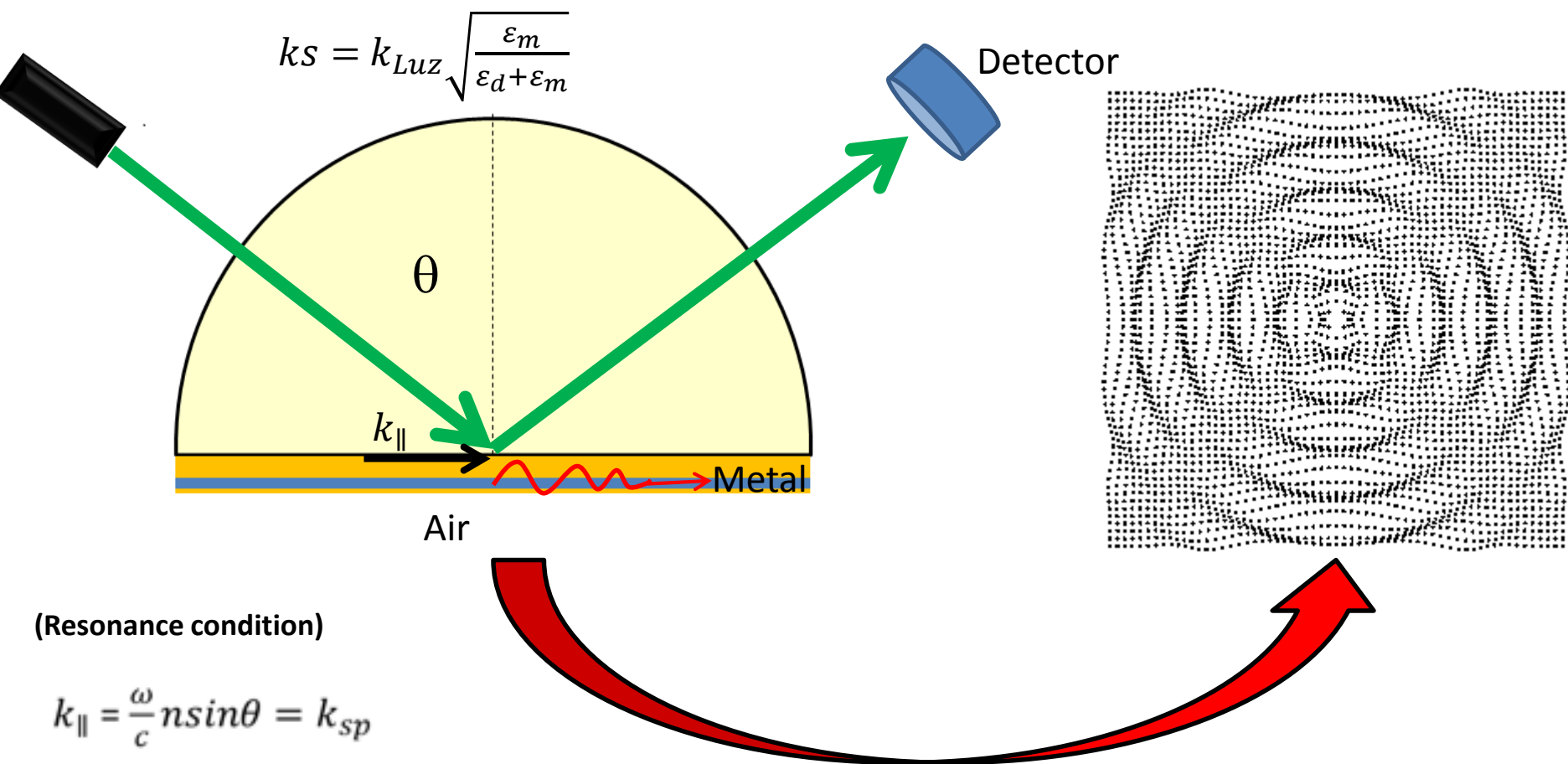


Progressing wave

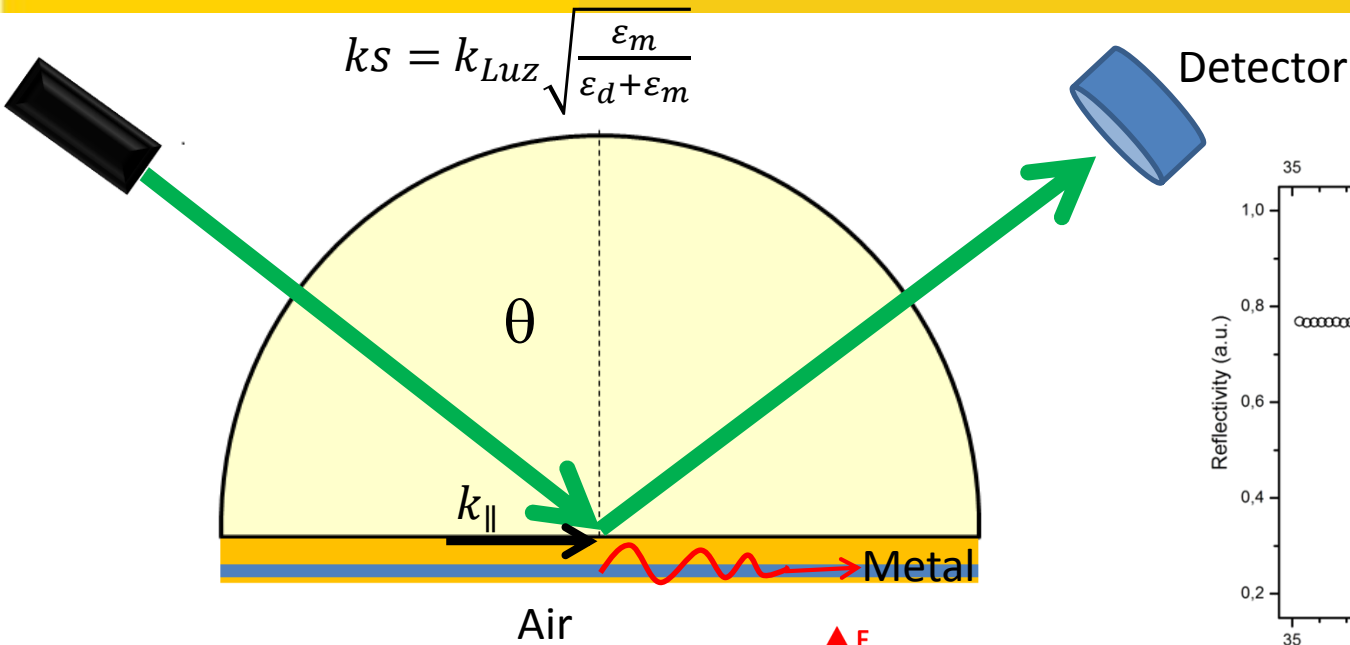
Surface-collective movement

Surface Plasmon Resonance (SPR)

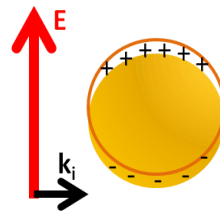
How plasmons are excited in Kretschmann configuration?



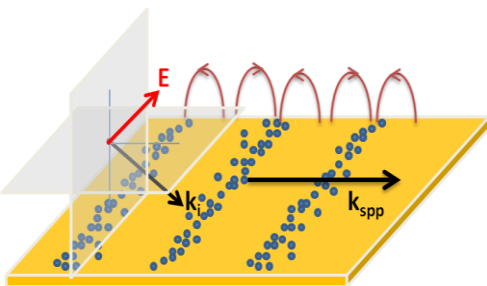
How are plasmons detected ?



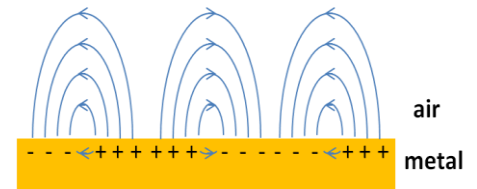
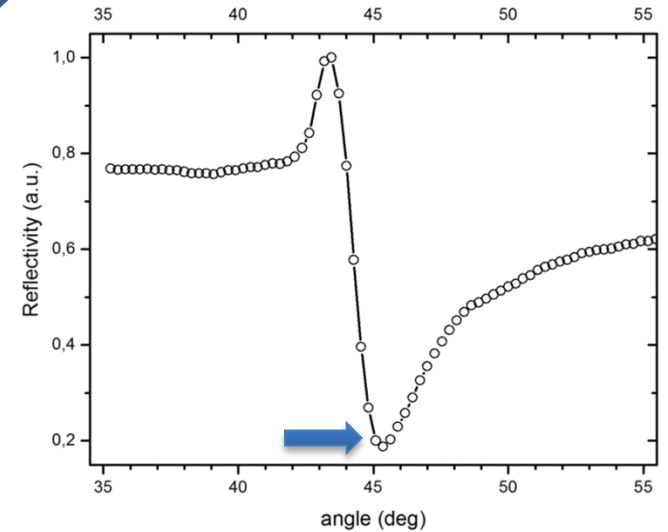
$k_{\parallel} = \frac{\omega}{c} n \sin \theta = k_{sp}$ (Resonance condition)



LSP – localized plasmons
frequency matching
Absorption spectrum



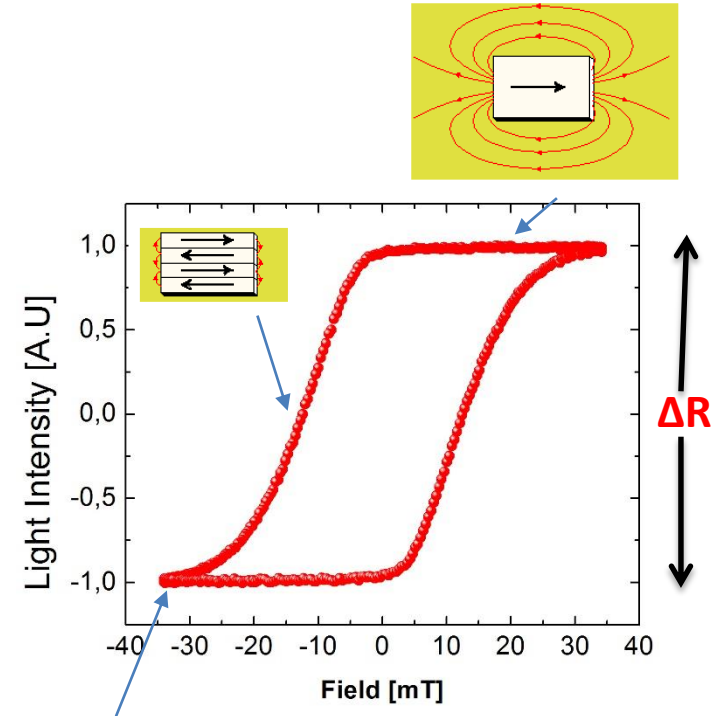
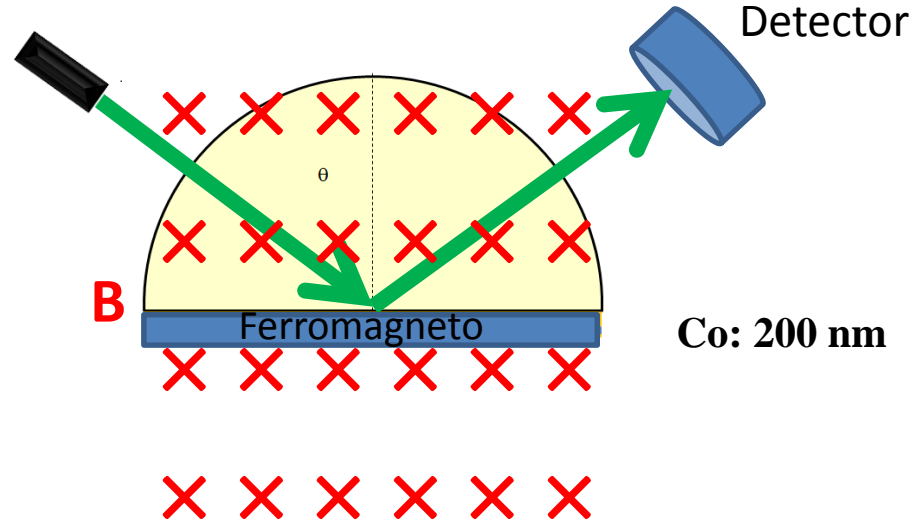
Collective charge oscillations at the metal-air(2D) interface in resonance with incident photons.



Strong confinement (below wave length)

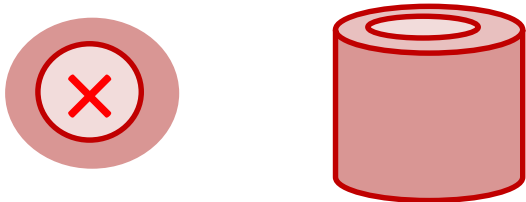
SPP – Propagating Plasmons
frequency + momentum matching

Magnetic optic Kerr Effect (MOKE)



Transversal Configuration.- Reflected light of a magnetic material shows variation in intensity as function of applied magnetic field.

This is due to that the dielectric properties depend on the material's magnetic moment.



$$\Delta R = R(+M_y^s) - R(-M_y^s)$$

What happens with MOKE when plasmons are present?

Multilayered [1]
(homogeneous)

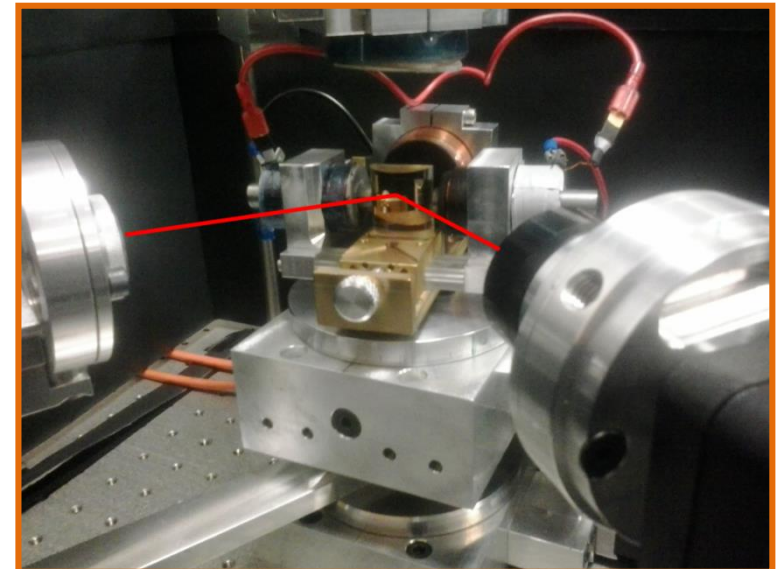
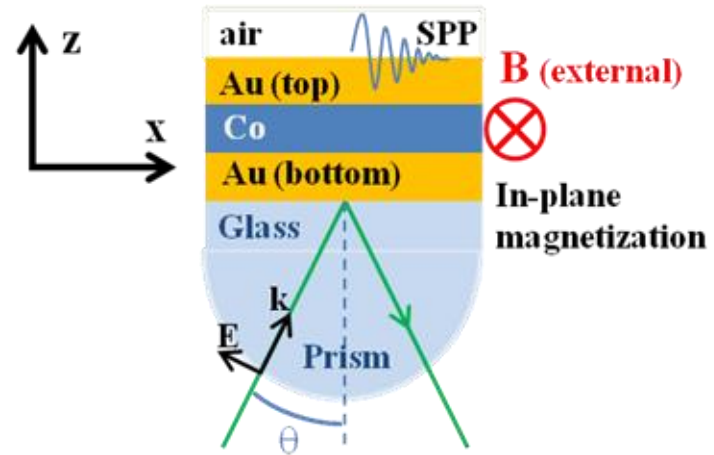
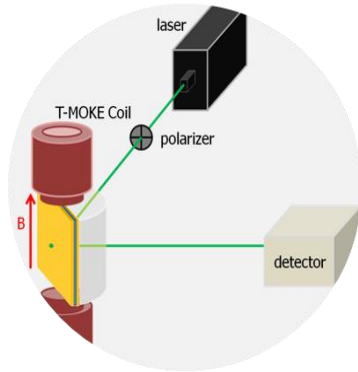
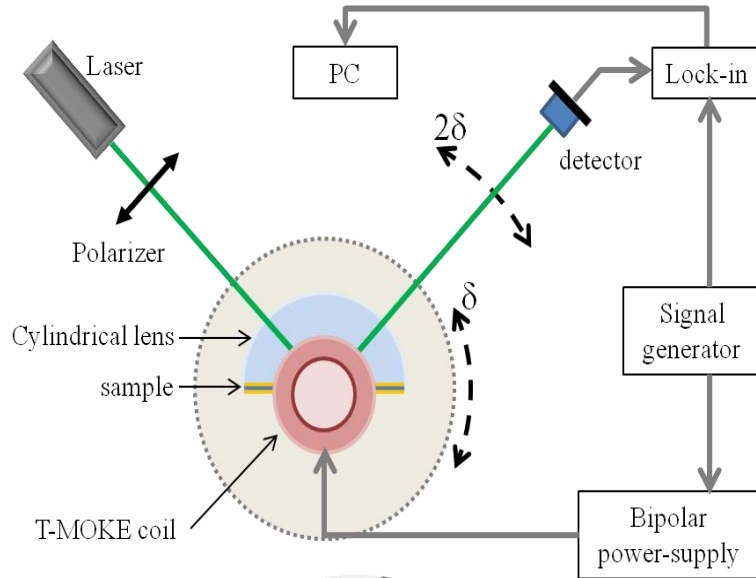


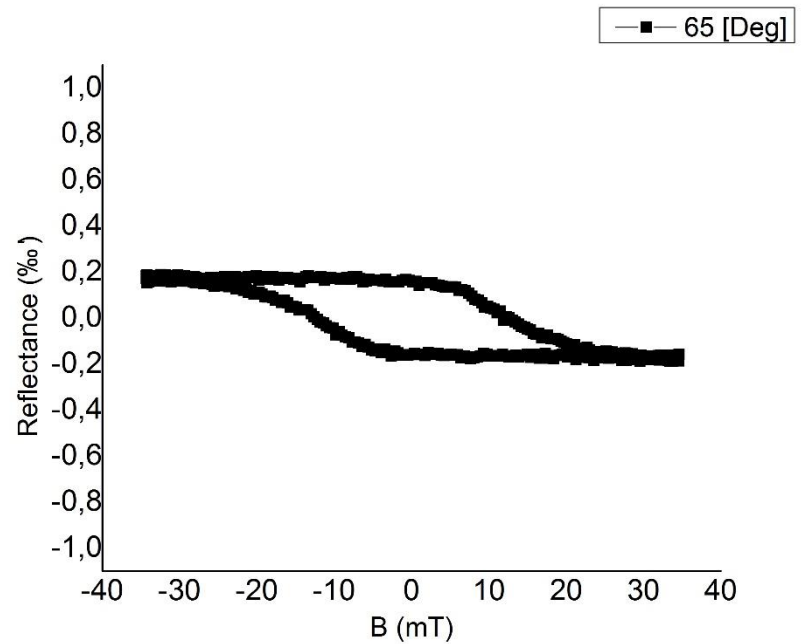
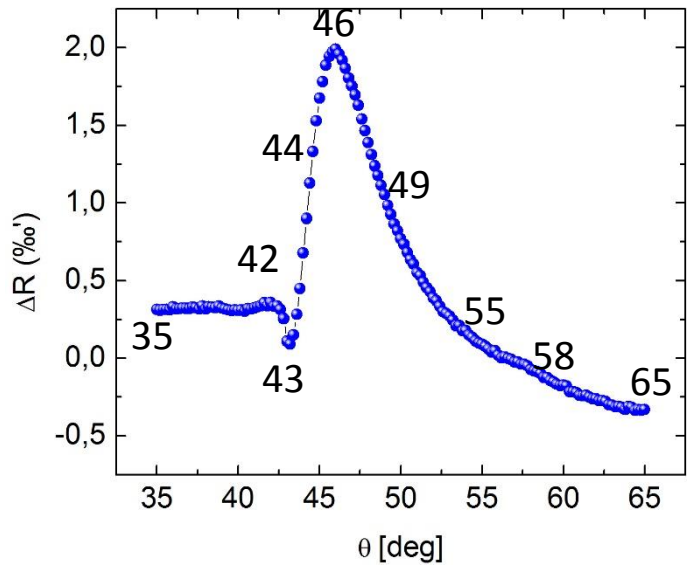
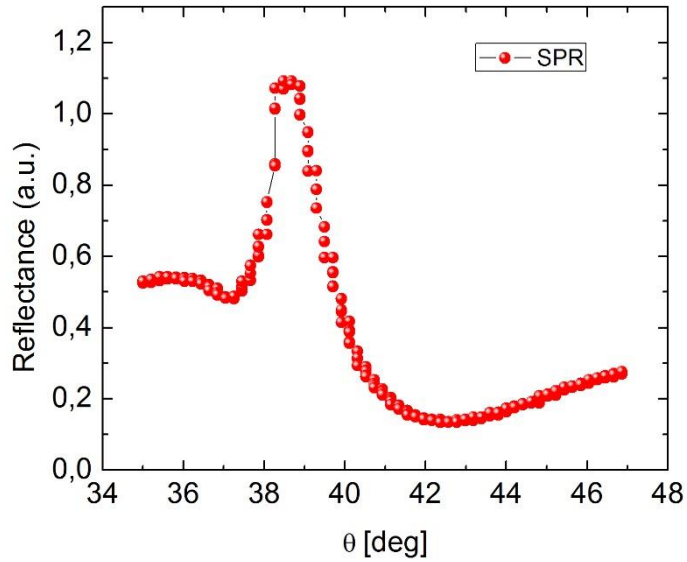
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+
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Nanodisks [4]

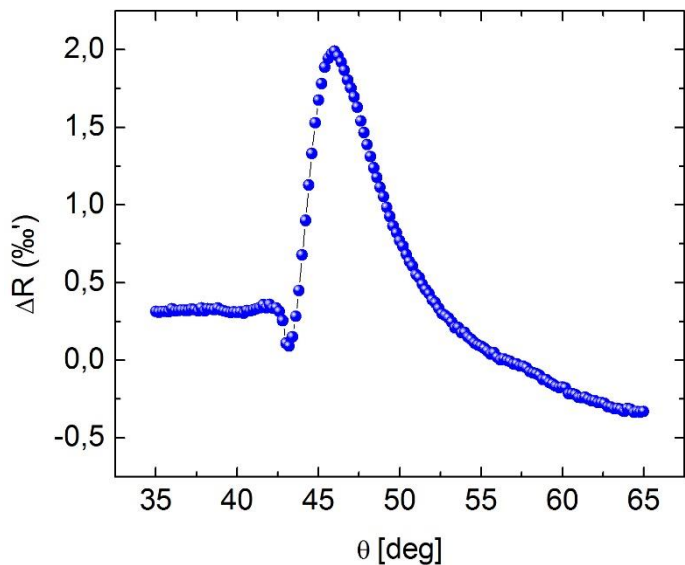
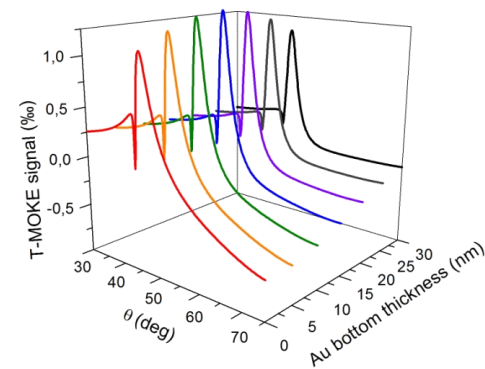
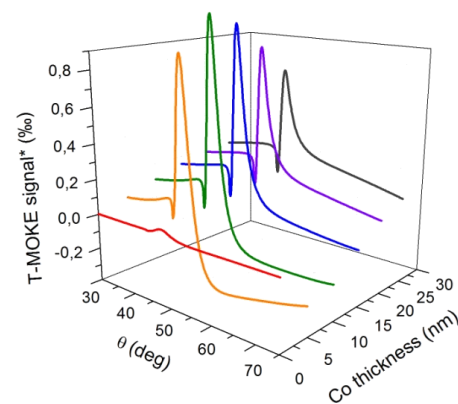
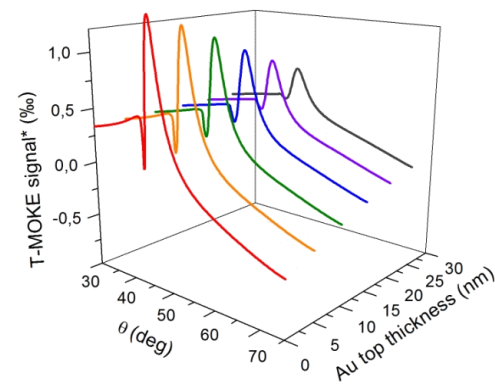
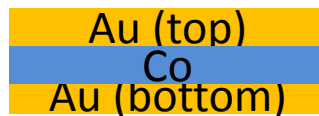
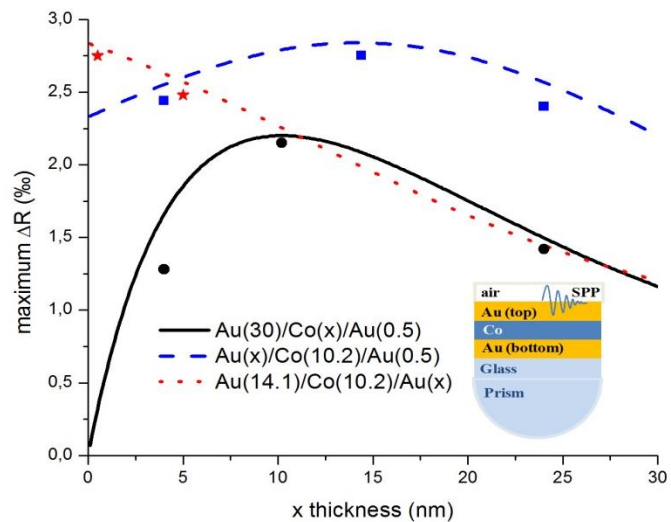


How does the experiment is done?



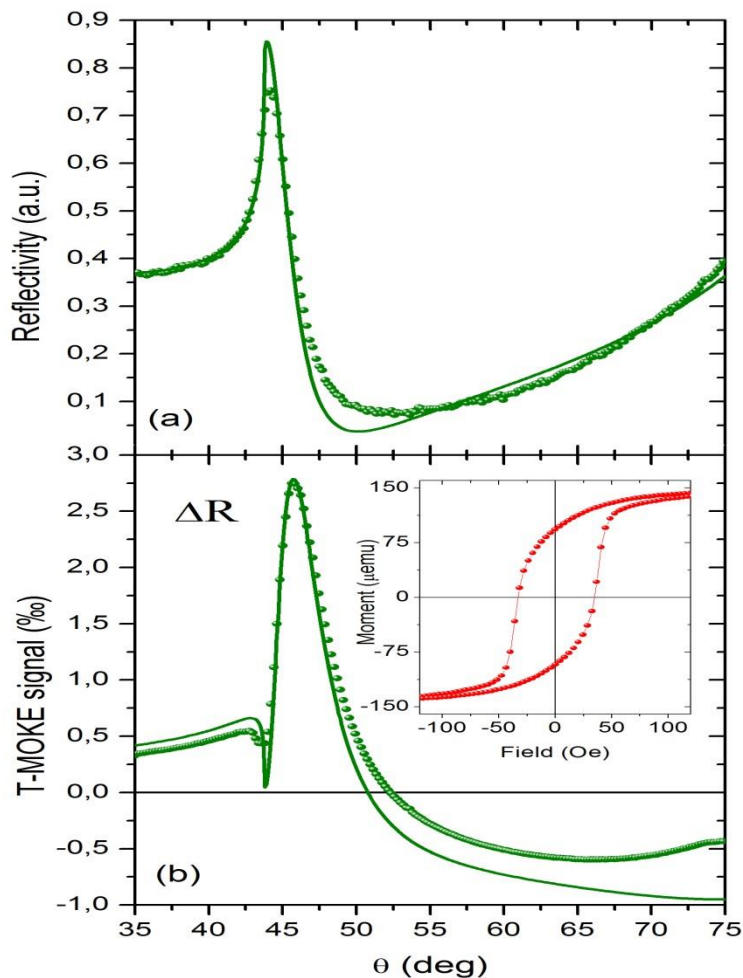


Maximización del efecto MOKE con plasmones

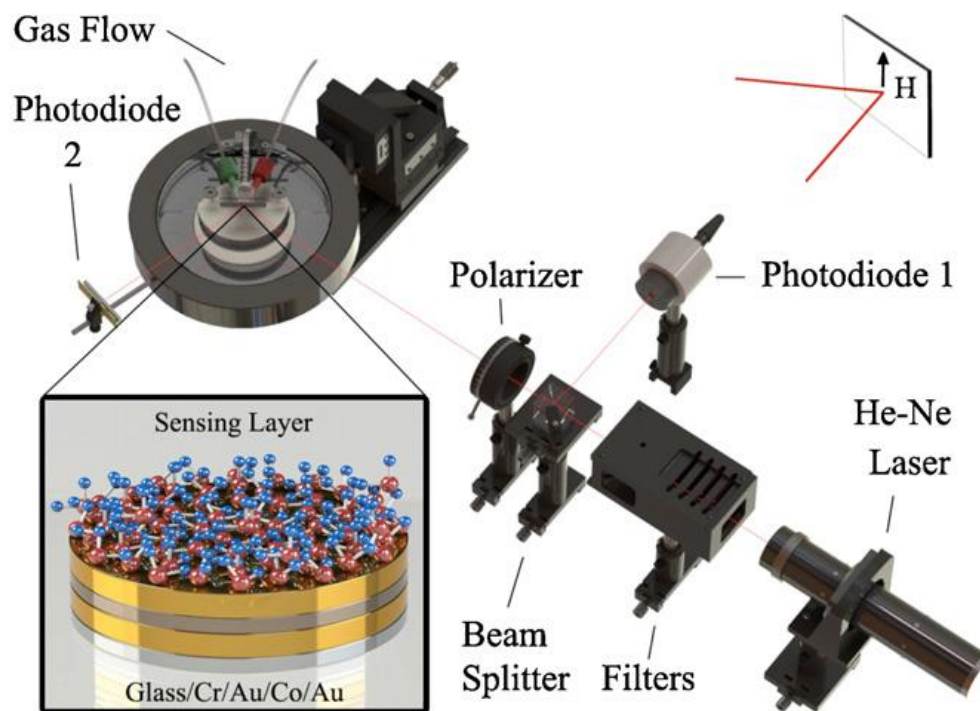


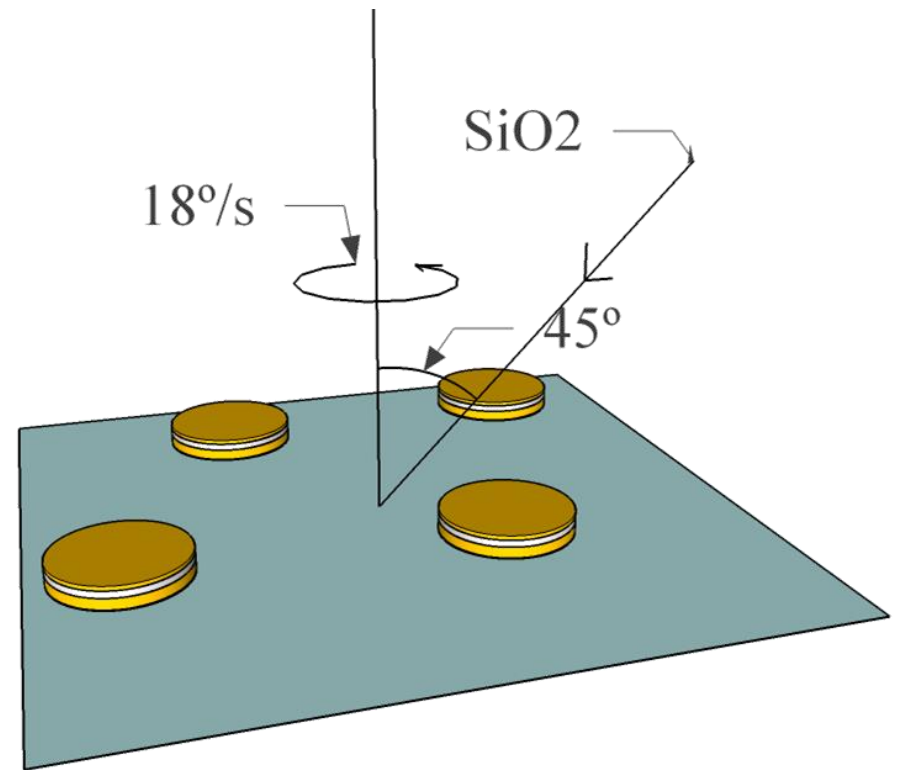
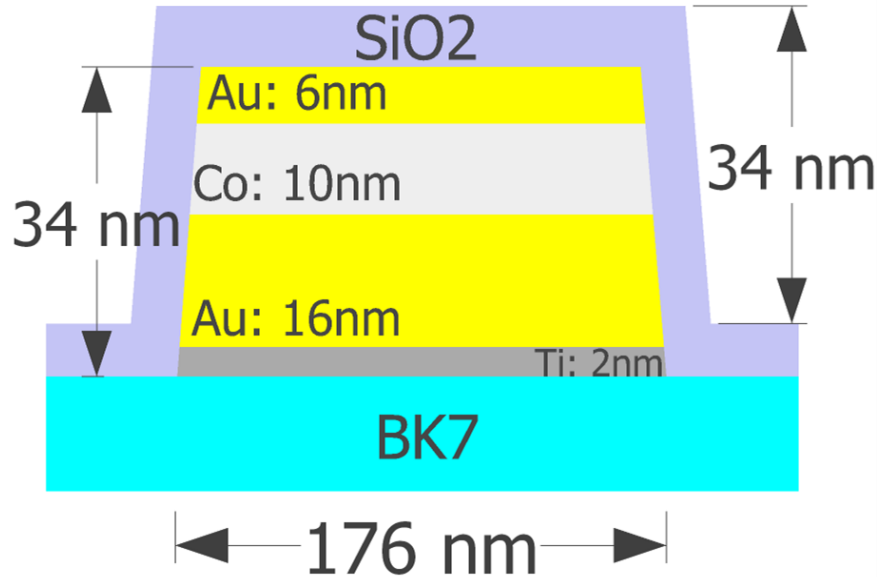
$$\Delta R = R(+M_y^S) - R(-M_y^S)$$

Au(14.1)/Co(10.2)/ Au(0.5).



- MO-SPR sensors



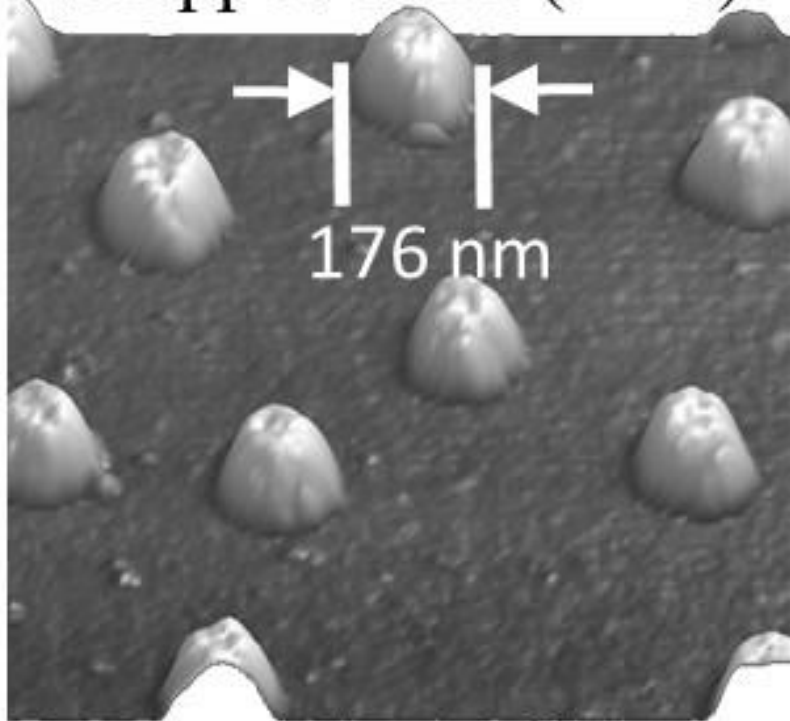


C. A. Herreño-Fierro and E. J. Patiño, "Maximization of surface-enhanced transversal magneto-optic Kerr effect in Au/Co/Au thin films", PSSb, **252**, 2, 316–322 (2015)

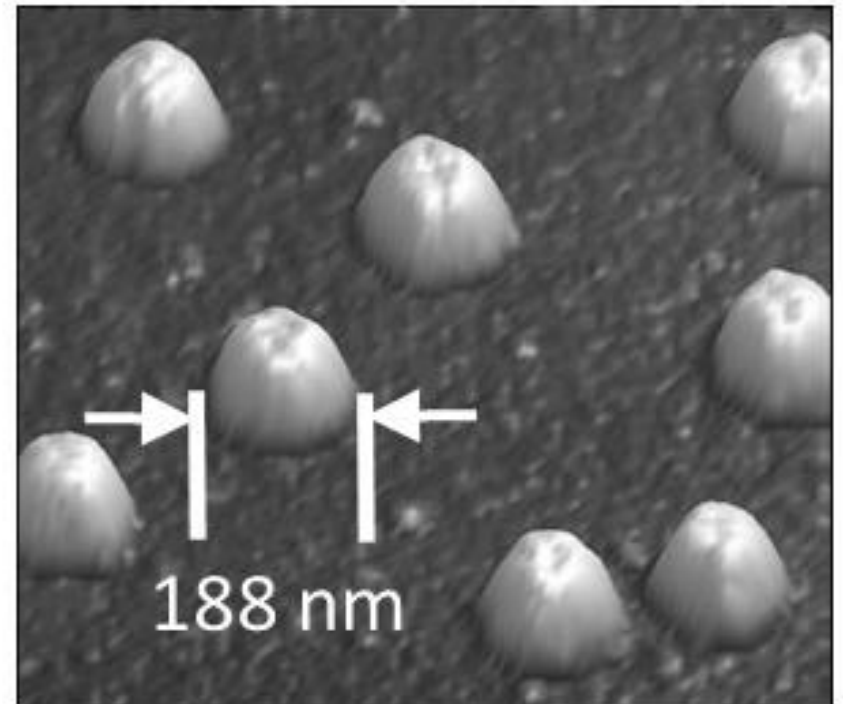
Characterization:

Morphology

Stripped disks ($t = 0$)

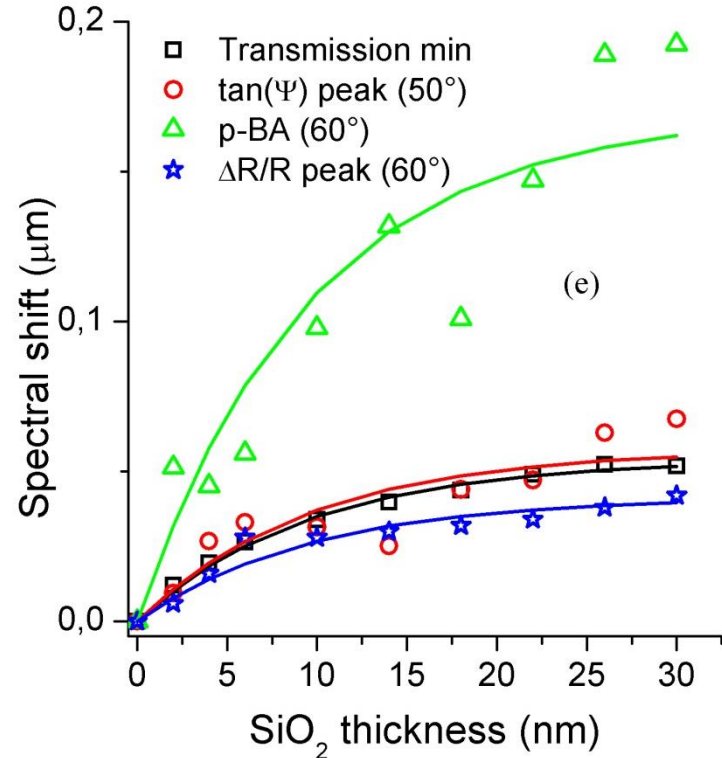
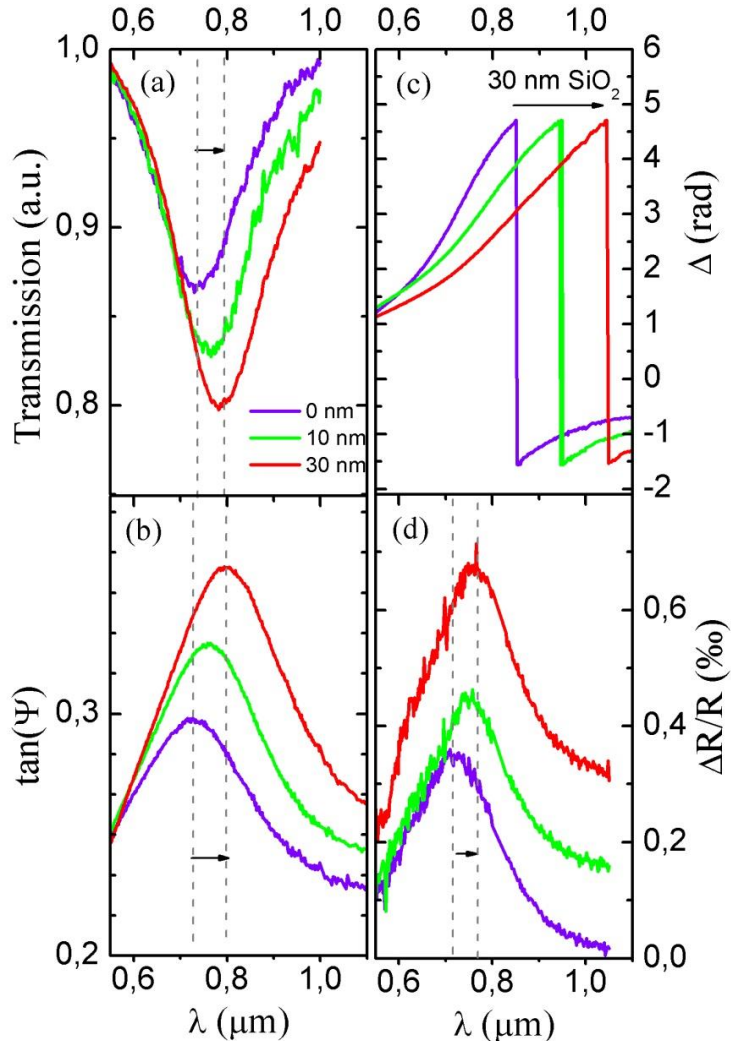


Silica coating ($t = 8$ nm)



AFM images

What are the results?



C. Herreño, E. J. Patiño, A. Cebollada, G. Armelles G. *Applied Physics Letters* 108 (2), pp. 0211091-0211094. 2016

Conclusions

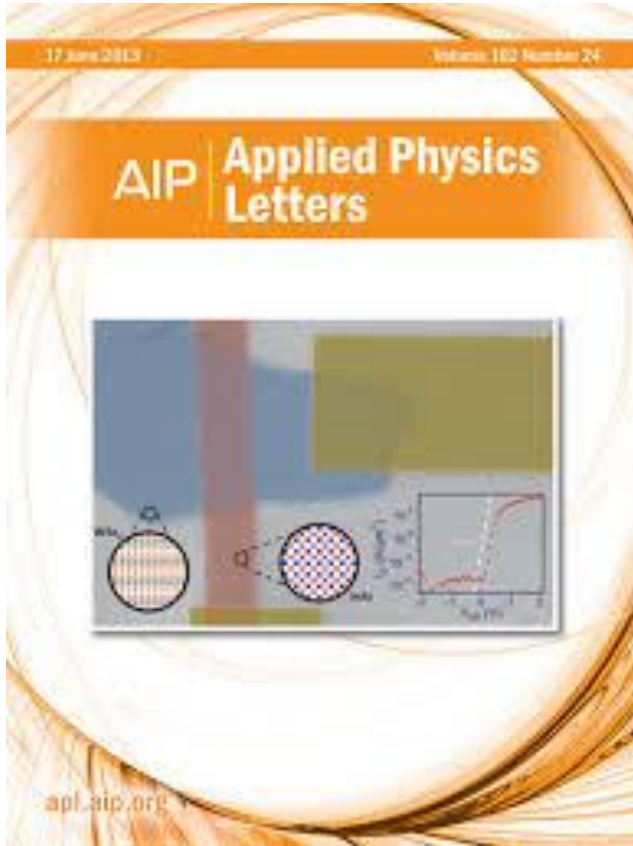
- It is possible to maximize the MOKE signal in structures M/F/M by manipulation of relative thicknesses of each layer.
- Nano disk of M/F/M structures show the largest sensitivity to SiO₂ deposition.

Quantum tunneling: How long does it take ?



Edgar J. Patiño

Departamento de Física

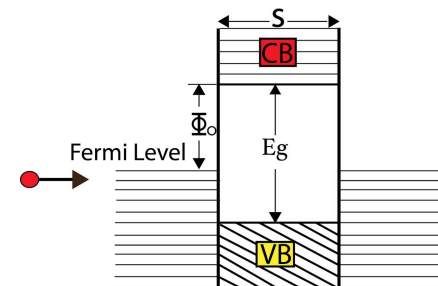


E. J. Patiño and N. Kelkar “**Experimental determination of tunneling characteristics and dwell times from temperature dependence of Al/Al₂O₃/Al junctions**”
Applied Physics Letters 107 (25) 2015

Not possible without the help of:

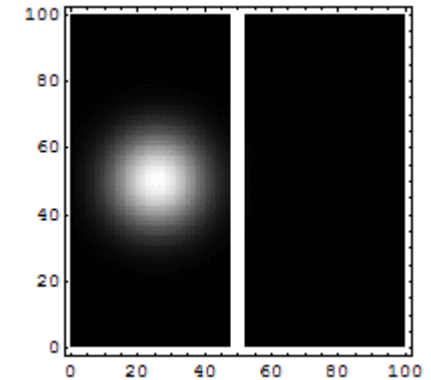
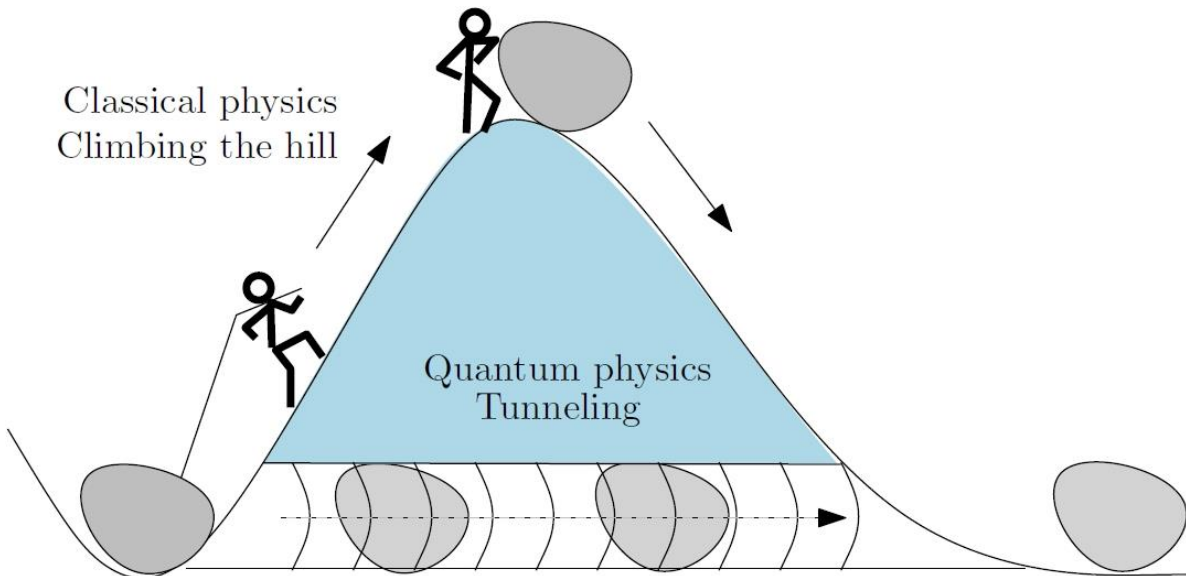


Neelima Kelkar



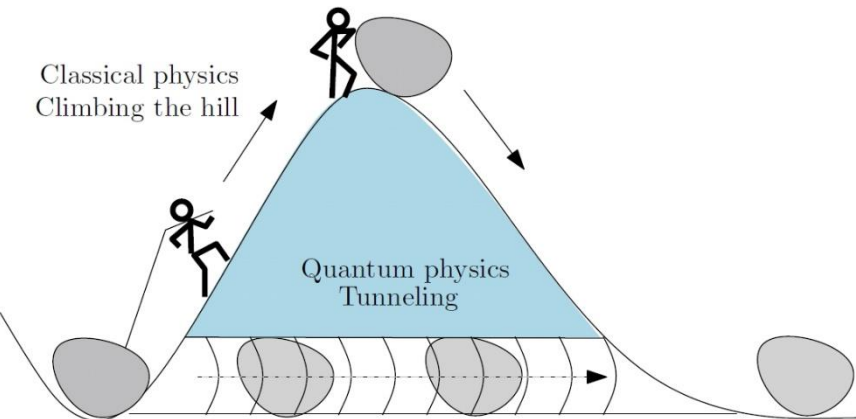
- **Introduction and Motivation**-> Quantum Tunneling.
Why tunneling is important in solid state physics?
Some preliminary works...
- **Experiments Description**-> Additional information
that can be extracted from tunneling experiments
- **Tunneling Dwell time determination**
- **Conclusions**

What is quantum tunneling

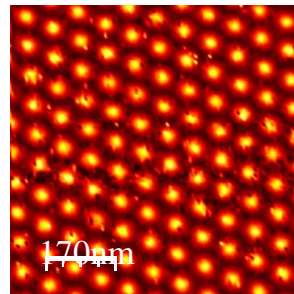
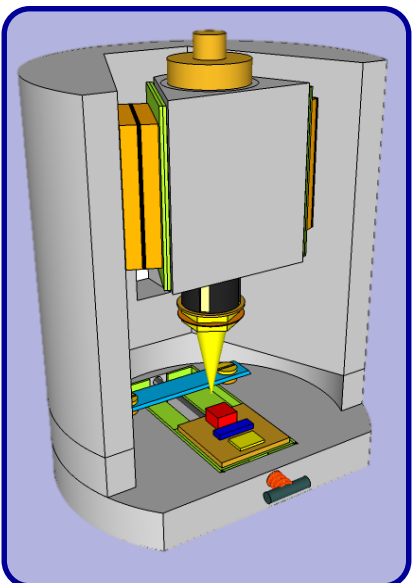
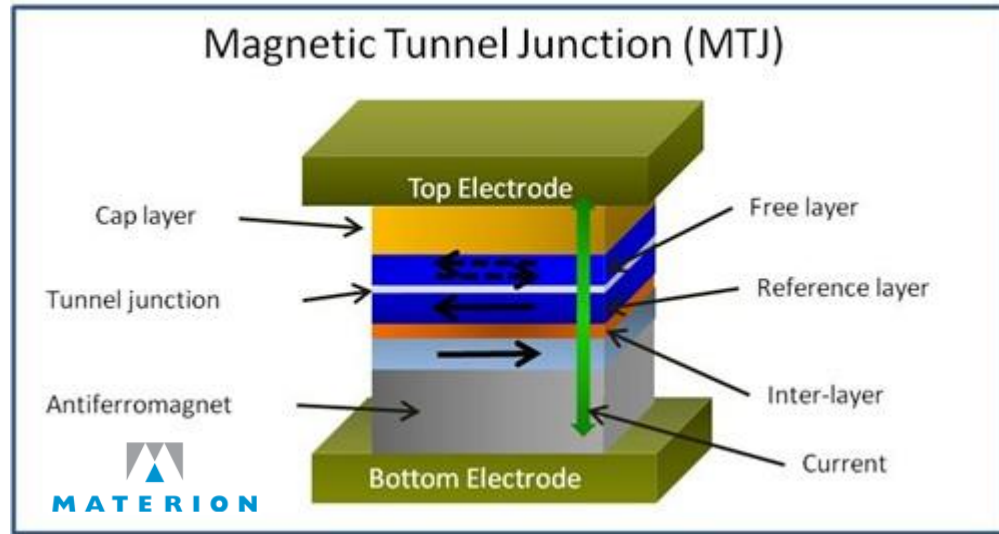


Electron wave packet propagation
Source: Wikipedia

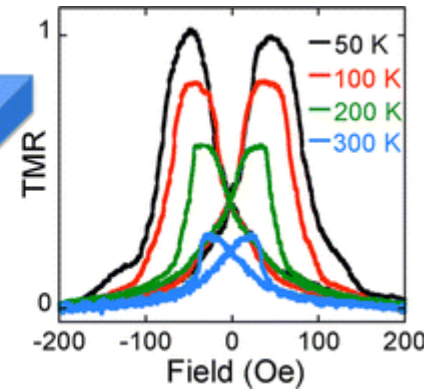
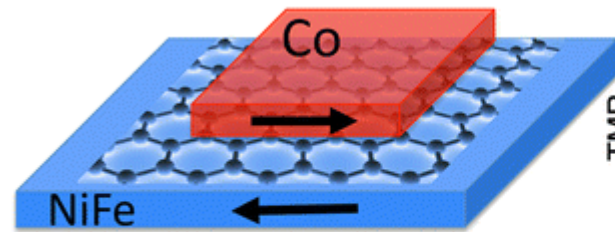
What is quantum tunneling?



Source: tech for space

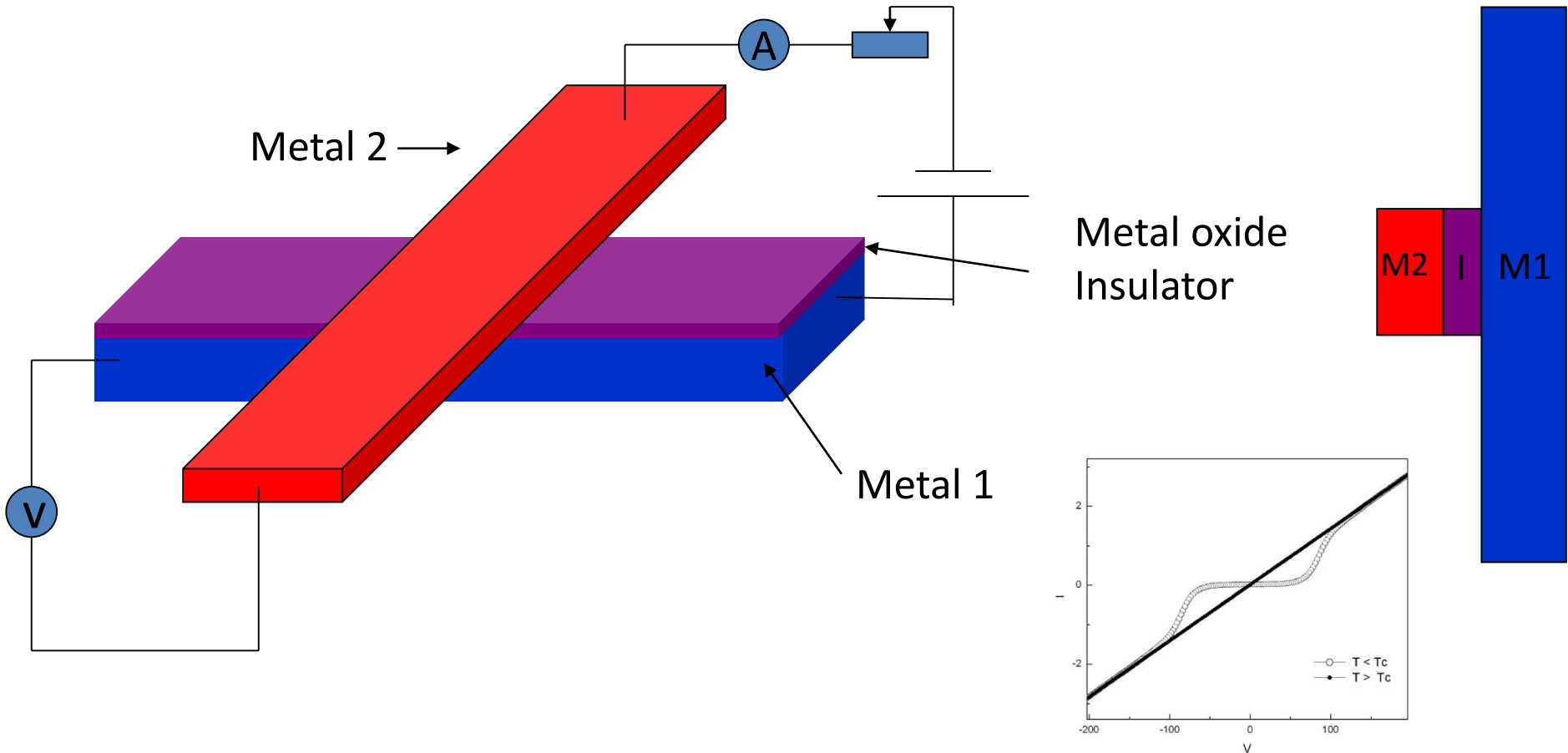


Vortex images
STM
shared
by Edwin Herrera



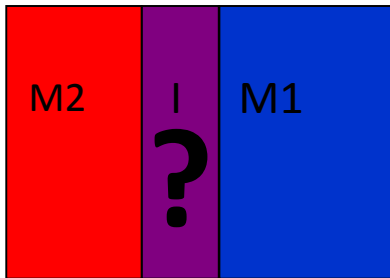
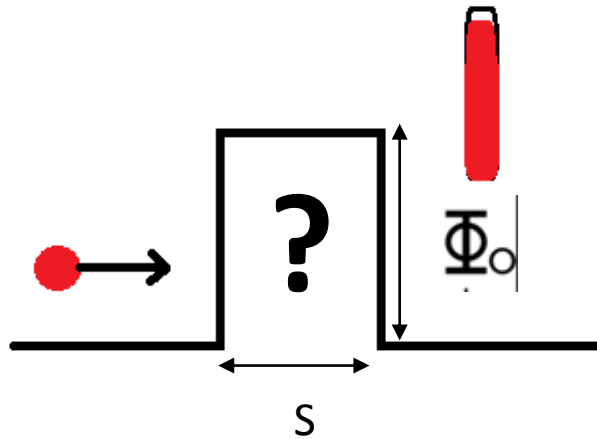
Graphene As a Tunnel Barrier: Graphene-Based Magnetic Tunnel Junctions Nano Lett., 2012, 12 (6), pp 3000–3004 (2012)

How to make a solid state tunnel junction ?



These structures can be fabricated utilizing mechanical masks or standard optical lithography techniques

What people knew before?



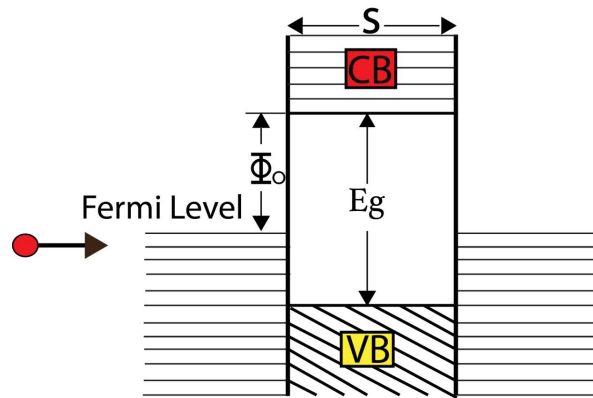
- **Barrier height** decreases with increasing temperature (up to 77 K)....?
- CONTROVERTIAL EXPLANATIONS
 - A) Is Al_2O_3 barrier height temperature dependence?
 - B) Is there a change in the space charge in dielectric?
 - C) Are there trap levels in the insulator?
- Two reports on **barrier width** temperature variation -> NO EXPLANATION (electron effective mass, maybe??)

Difficult to produce continuous Al_2O_3 -> pinholes, hot spots and barrier shorts found!

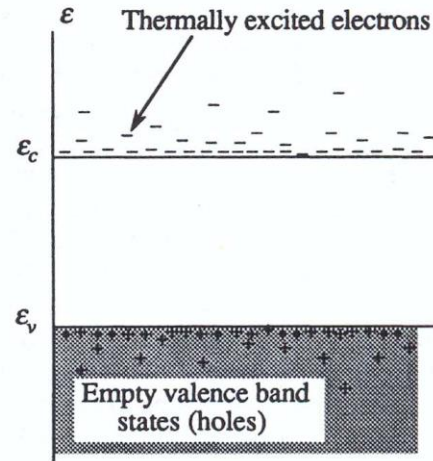
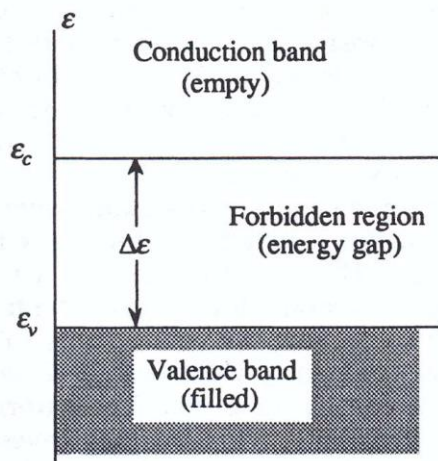
- [1] K. H. Gundlach and A. Wilkinson, Phys. Stat. Sol. (a) **2**, 295 (1970).
- [2] O. L. Nelson and D. E. Anderson, J. Appl. Phys. **37**, 77 (1966)
- [3] J. Kadlec, Solid-State Electronics **17**, 469 (1974).
- [4] V. D. Das and M. S. Jagadeesh, Phys. Stat. Sol. (a) **66**, 327 (1981).
- [5] D. Meyerhofer and S. A. Ochs, J. Appl. Phys. **34**, 2535 (1963).

What do we need to know well in order to extract tunneling time ?

- Barrier width (s) and barrier height (ϕ_0)



How to extract information from the barrier?



30 nm

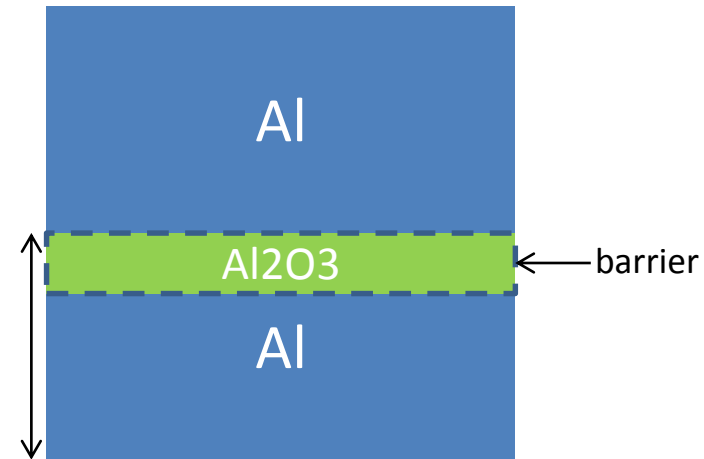
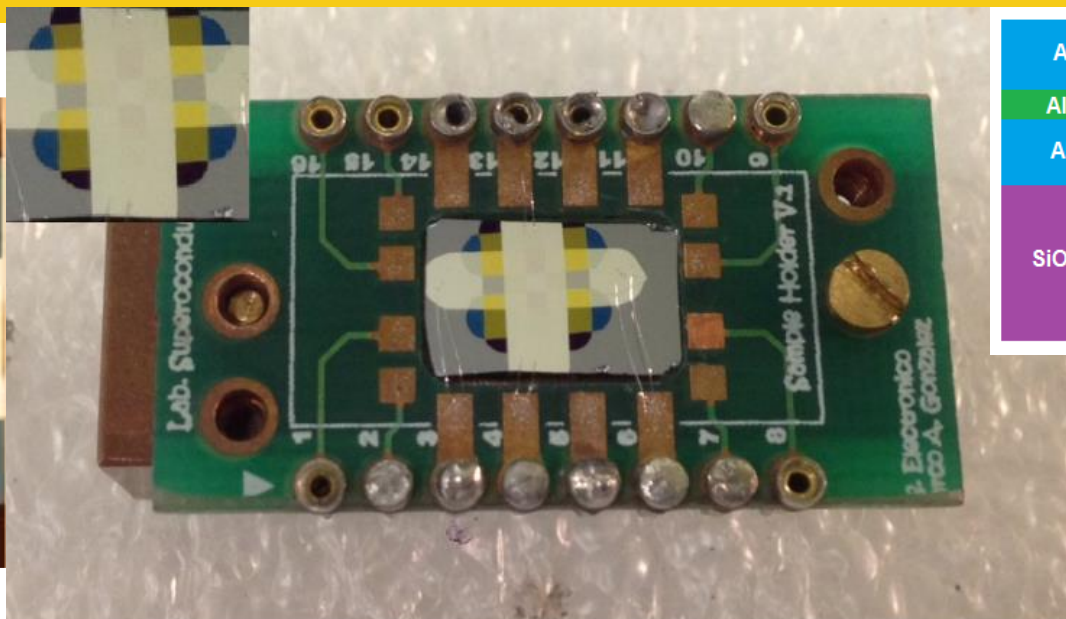


Figure 9.1 Conduction and valence bands of an intrinsic semiconductor (a) at temperature absolute zero, and (b) at room temperature, illustrating thermally excited electrons and empty valence band states associated with holes.



Al (30 nm)
Al ₂ O ₃ (2 nm)
Al (30 nm)
SiO ₂ (~ 300 nm)

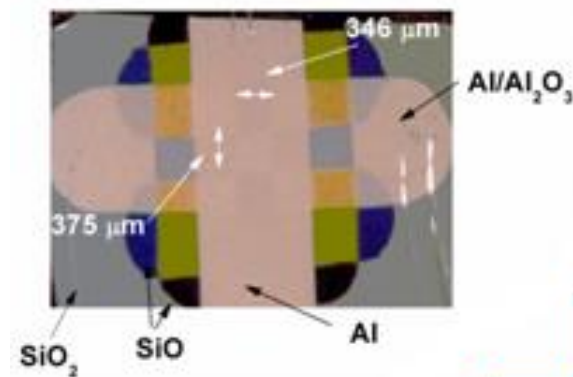
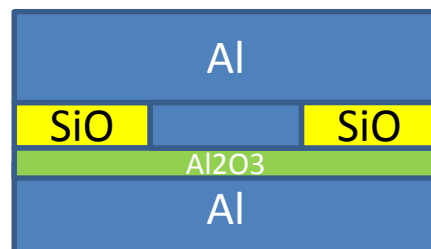
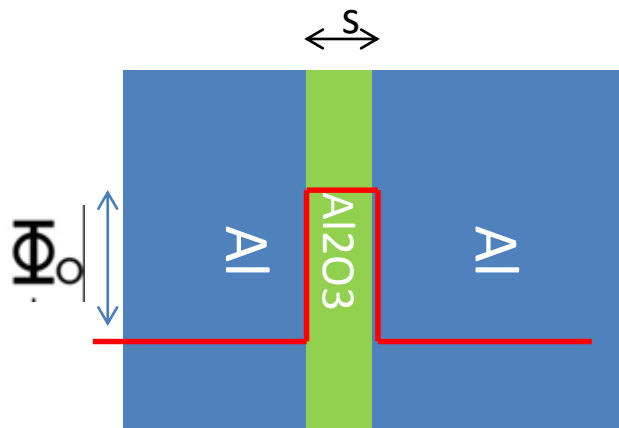
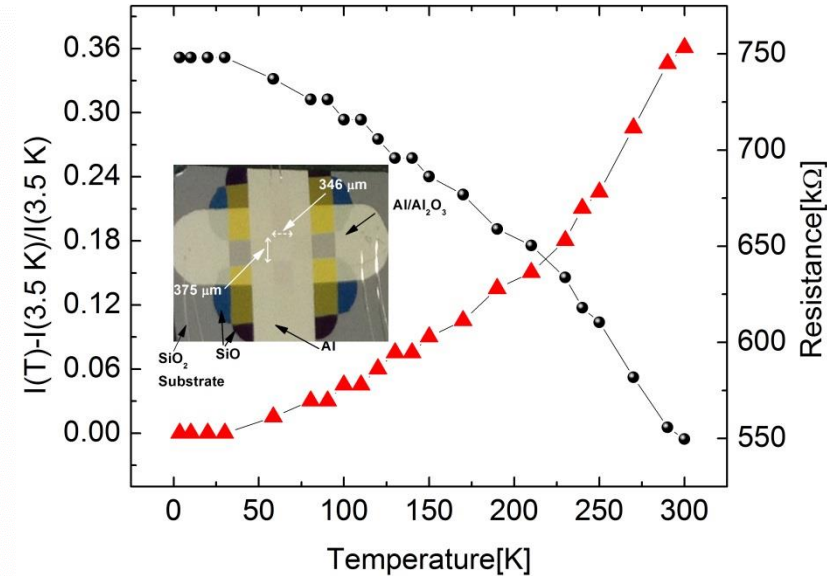
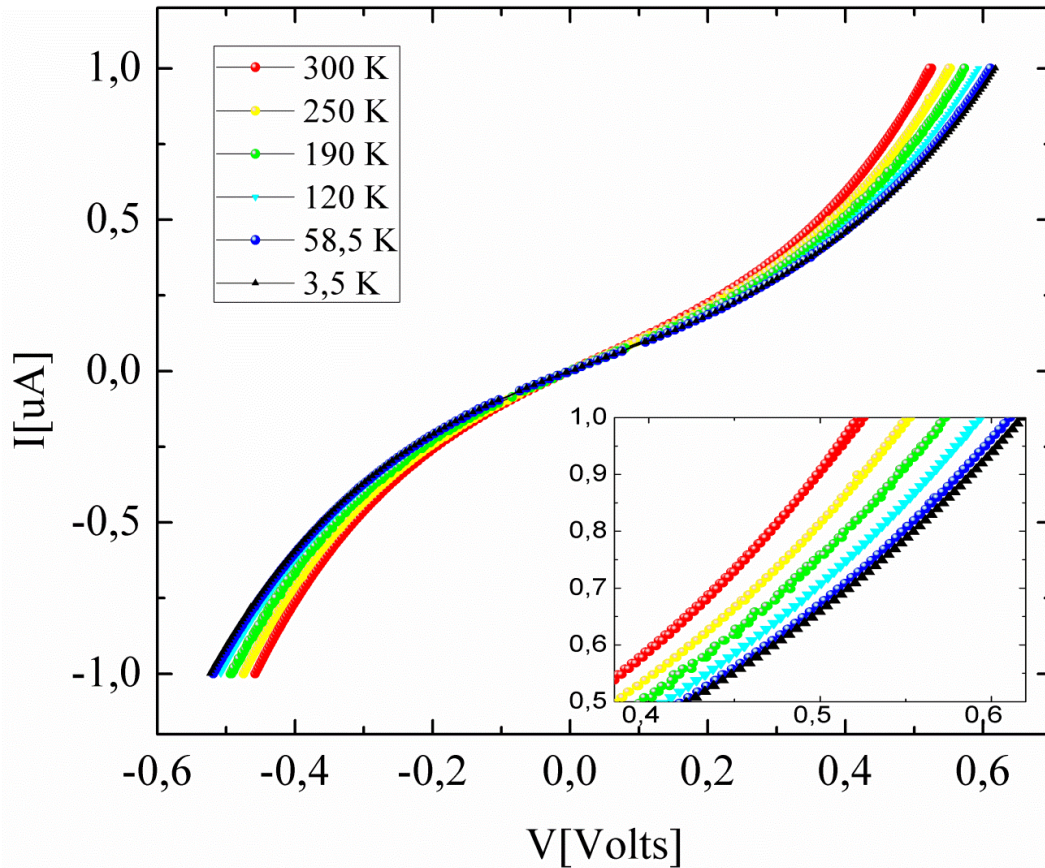


Figure 3: Photograph of planar junctions made using a mask evaporation technique in the system shown in figure. 1.

What are the results?



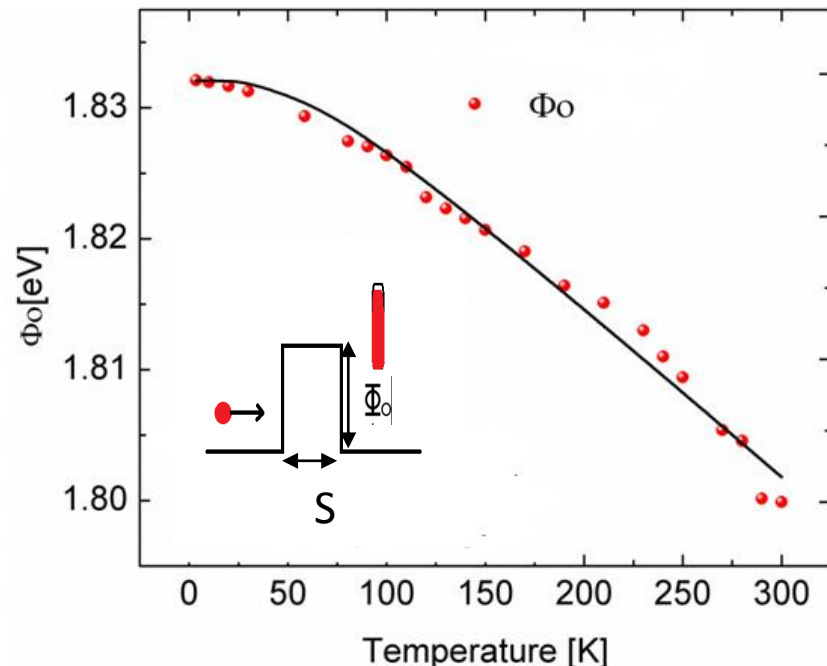
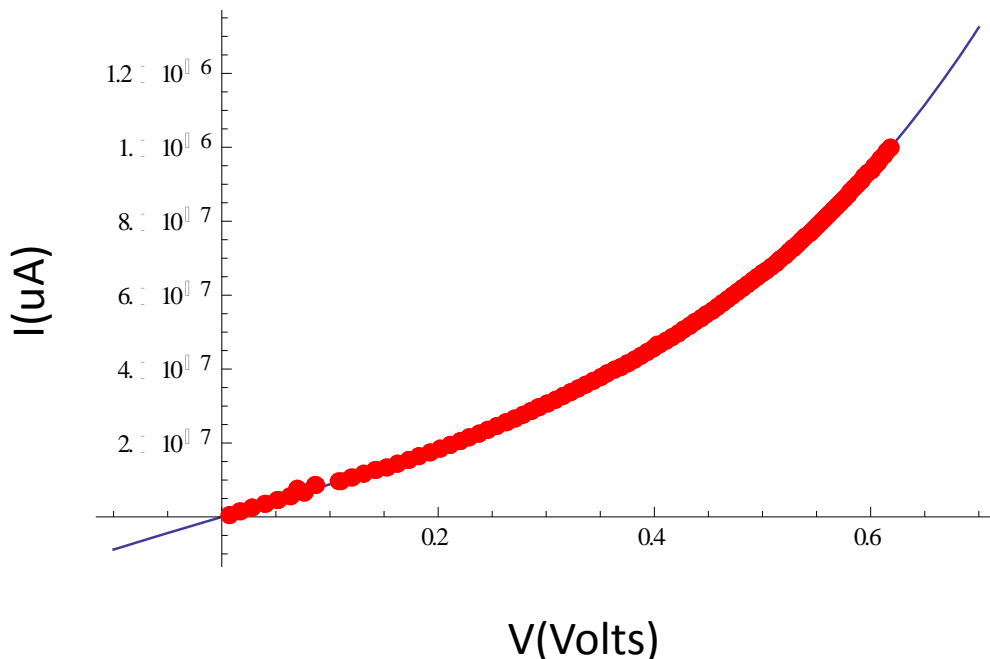
Junction Resistance (triangles) and Tunneling current variation (circles) vs temperature at a bias voltage of 0.5 V

I-V characteristics of Al/Al₂O₃/Al junctions at different temperatures; inset shows zoom in view upper voltages.

Small temperature dependence!

How good is the theoretical fit with the experiment ?

$$J = \left(\frac{e}{2\pi\hbar s^2} \right) \left\{ \left(\varphi_0 - \frac{eV}{2} \right) \exp \left[-\frac{4\pi s}{\hbar} (2m)^{\frac{1}{2}} \left(\varphi_0 - \frac{eV}{2} \right)^{\frac{1}{2}} \right] - \left(\varphi_0 + \frac{eV}{2} \right) \exp \left[-\frac{4\pi s}{\hbar} (2m)^{\frac{1}{2}} \left(\varphi_0 + \frac{eV}{2} \right)^{\frac{1}{2}} \right] \right\}$$



	Estimate	Standard Error
φ_0	2.178	0.00249147
s	19.1074	0.0109113

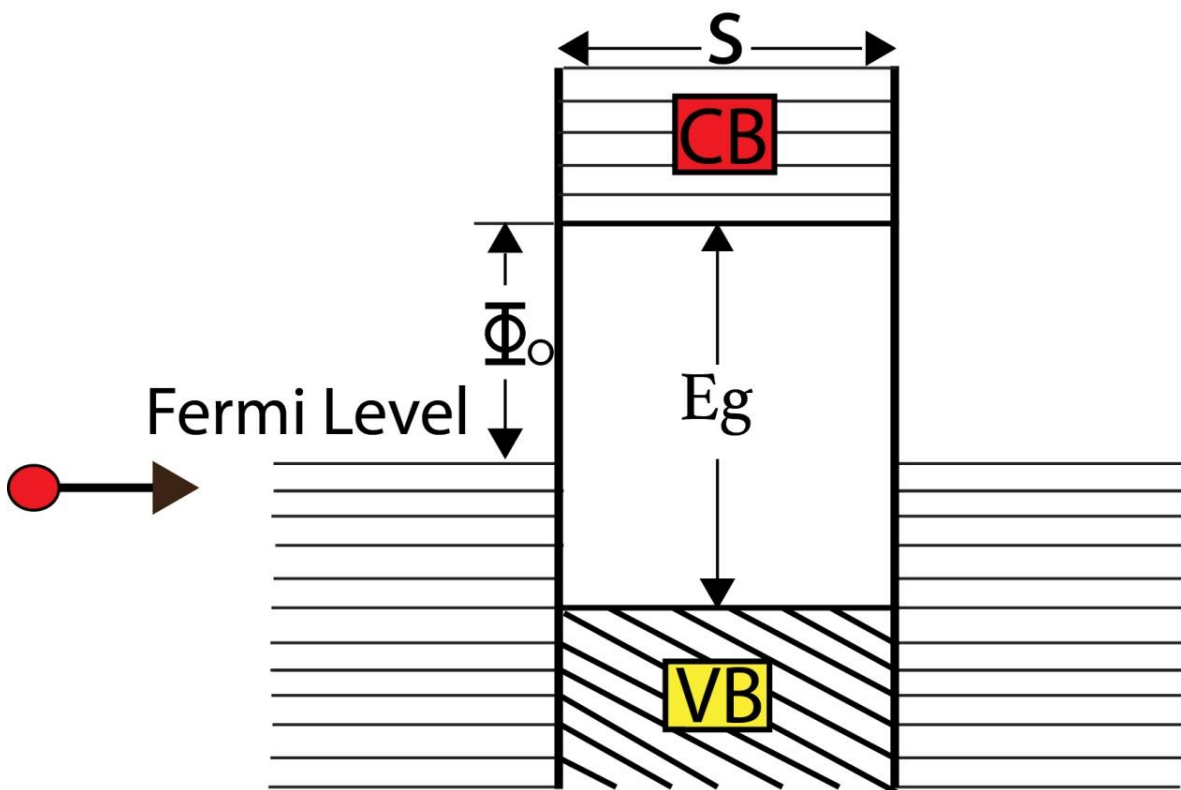
A ≈ 375X346 (μm)²

No pinholes or hot spots!

S ≈ 20.8 Å

Barrier width → Fixed at all Temperatures!

Why is Φ_0 changing with temperature ?



Assuming a linear relationship:

$$E_g(T) = \gamma \Phi_0(T)$$

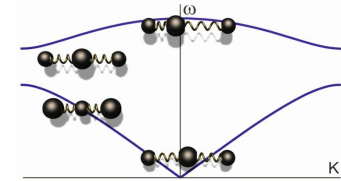
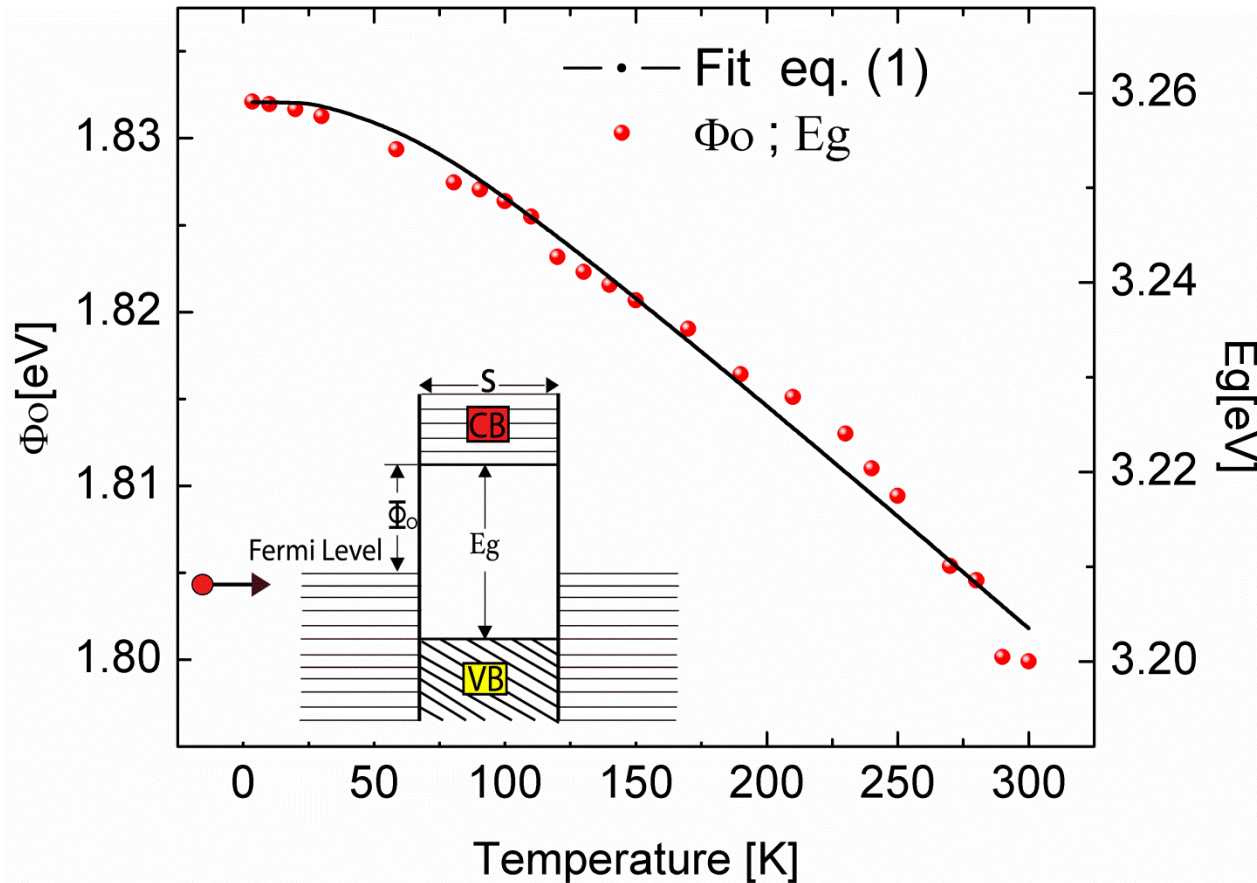
$$\frac{E_g(300\text{ K})}{\Phi_0(300\text{ K})} = \frac{3.2\text{ eV}^*}{1.8\text{ eV}} = 1.7$$

Is E_g changing with temperature as well?

* I. Costina and R. Franchy, Appl. Phys. Lett. 78, 4139 (2001)

Eq. 1

$$E_g(T) = E_g(0) - S \langle \hbar\omega \rangle [\coth(\langle \hbar\omega \rangle / 2kT) - 1]$$



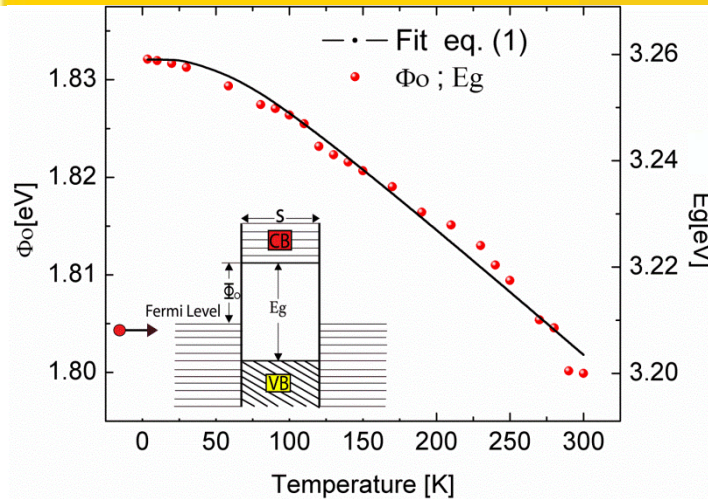
$$E_g(T) = \gamma \phi_0(T)$$

Eq. 1

	Estimate	Standard Error
E_{g0}	3.24348	0.00072269
S	1.16311	0.0613627
$\langle \hbar\omega \rangle$	0.0170526	0.00235379

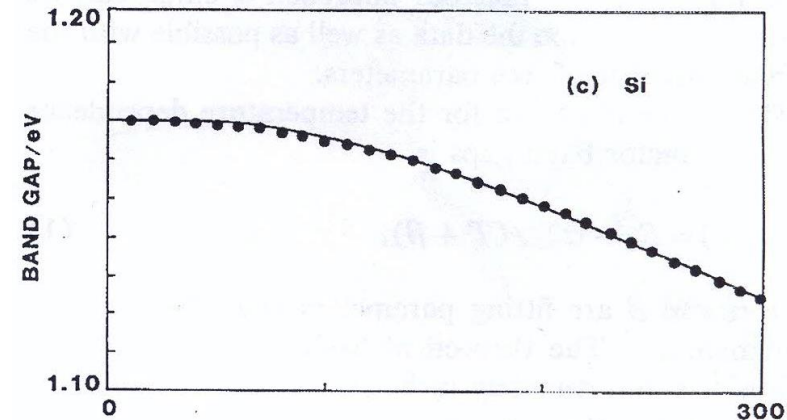
$$\underline{\text{Avg}[\omega] = 2.05 \times 10^{13} \text{ sec}^{-1}}$$

Comparing with other semiconductors: O'Donnell



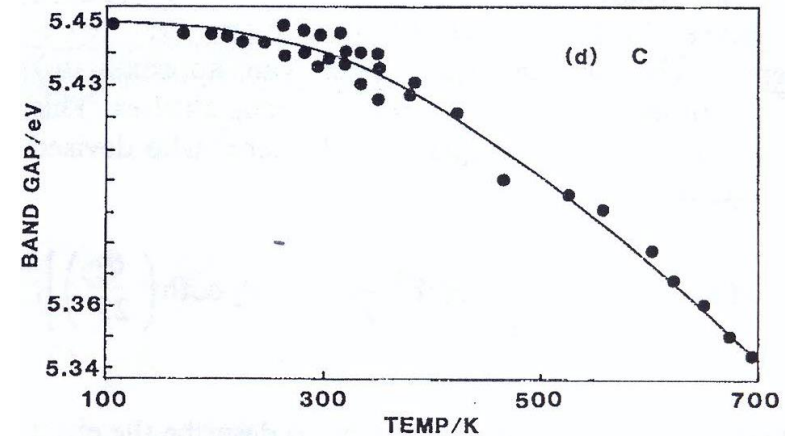
	Estimate	Standard Error
E_{g0}	3.24348	0.00072269
S	1.16311	0.0613627
$\langle \hbar\omega \rangle$	0.0170526	0.00235379

Average phonon energy



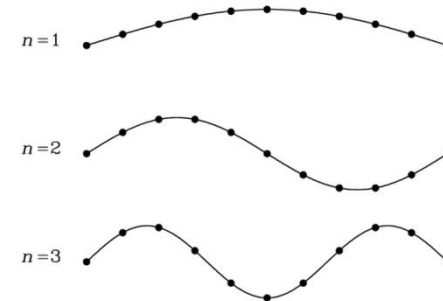
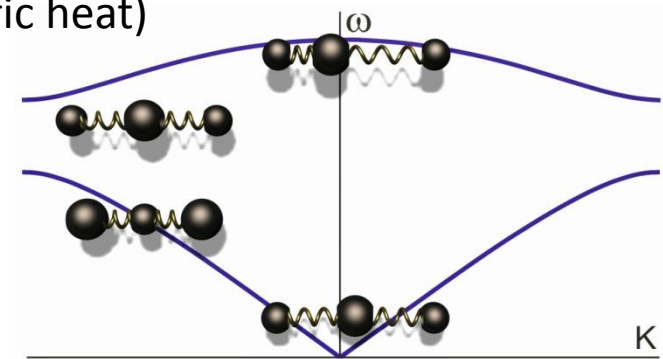
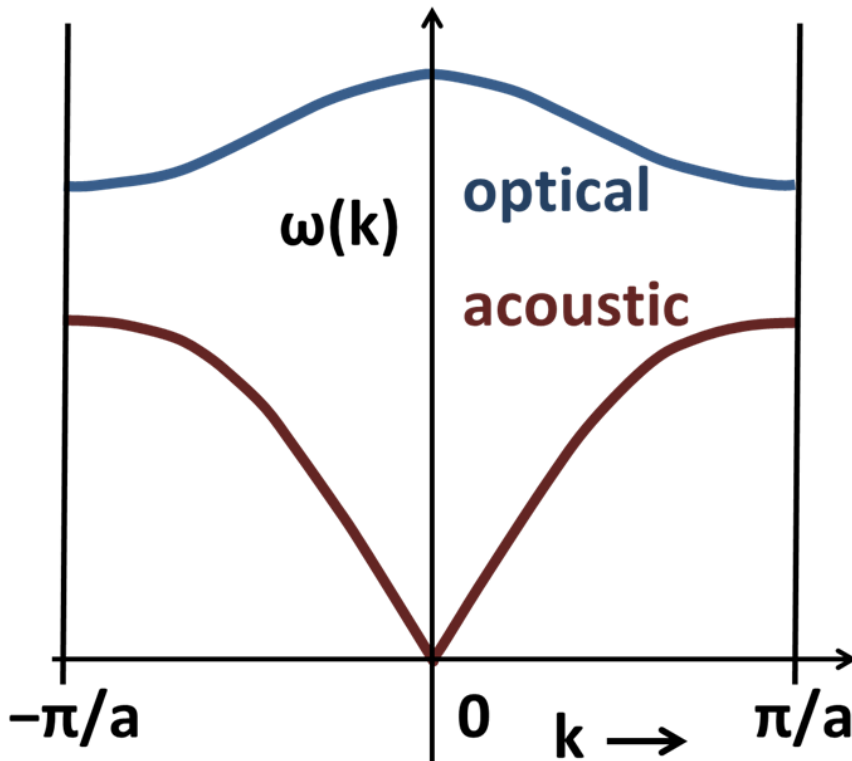
γ	$E_g(0)$ [eV]	S	$\langle \hbar\omega \rangle$ [meV]	$\langle \omega \rangle$ [$\times 10^{13} \text{sec}^{-1}$]
----------	------------------	-----	----------------------------------------	------------------------------------------------------------------

Al ₂ O ₃ Forward bias	1.78	3.26	1.414	13.5	2.05
Al ₂ O ₃ Back bias	1.84	3.24	1.163	17.1	2.59
Si ¹⁴	-	1.17	1.49	25.5	-
GaAs ¹⁴	-	1.52	3.00	26.7	-
GaP ¹⁴	-	2.34	3.35	43.6	-
C ¹⁴	-	5.45	2.31	94.0	-



Lets compare with other experiments....

Phonons- quantized atomic lattice vibrations (eg. Specific heat)



$$\text{Avg}[\omega] = 2.05 \times 10^{13} \text{ sec}^{-1}$$

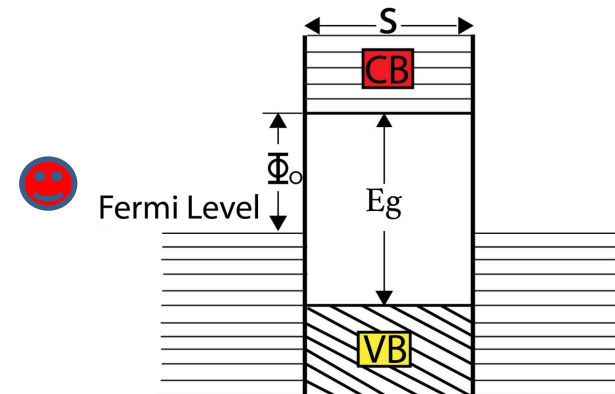
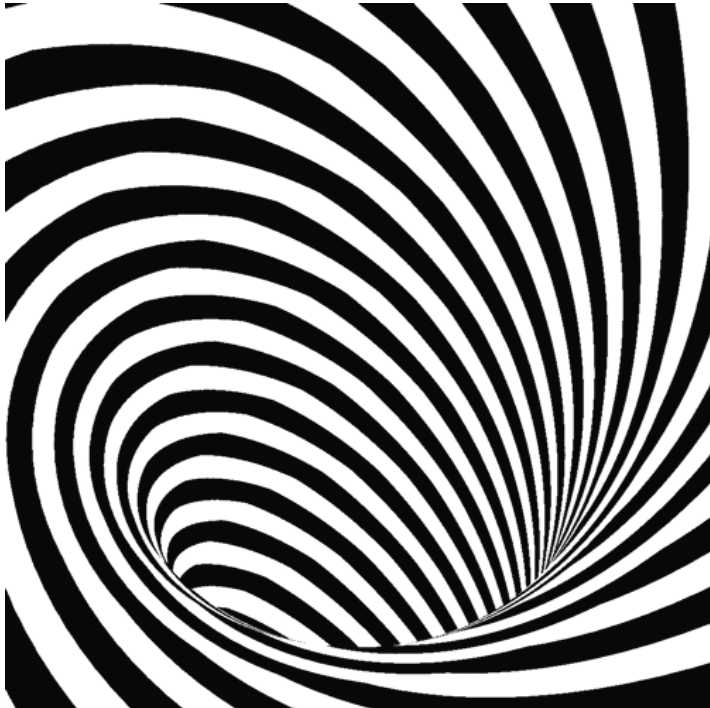
$$K = 2\pi/\lambda$$

sound velocity $v_{\text{Al}_2\text{O}_3} = 6.7 \times 10^3 \text{ m/s}$. Considering a value of $k = \pi/2a$ at the middle of the first Brillouin zone, from the expression $\omega = v_{\text{Al}_2\text{O}_3} k$;
 a value of phonon frequency **$\omega = 2.24 \times 10^{13} \text{ sec}^{-1}$ is obtained !**

We confirm..

Given that phonon frequencies are
correct we confirm.....

Barrier width “ s ” and height “ ϕ_0 ” are indeed correct!



<http://www.vdomck.org/2009/11/ssh-all-time.html>

How hard is to measure tunneling times?

PHYSICAL REVIEW B, VOLUME 64, 233311

Electron tunneling time measurement by field-emission microscopy

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Electron-tunneling time has been measured using field-emission microscopy (FEM). The analysis of the FEM images of the dopant samarium ions located inside the calcium fluoride coating onto the silicon nanotip gives the value of the perpendicular momentum distribution of emitted electrons. This distribution is a natural measure of the tunneling time: the more time an electron spends under the barrier, the narrower such a distribution is (Larmor clock experiment). For the barrier height of 1.7 eV and electric-field strength ranging from 0.55 to 0.7 V/nm, the tunneling time ranges from 6 to 8 fs.

$$\sim 1 \times 10^{-15} \text{ s}$$

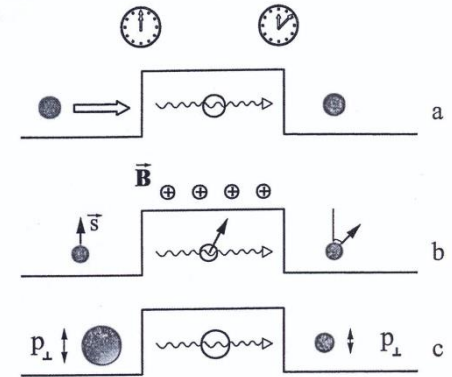


FIG. 1. The idea of the Larmor clock tunneling time measurement. One should invent a clock that starts to measure at the beginning of the barrier crossing and finishes at the end (a). Particle spin vector s rotation in the perpendicular magnetic field B , superimposed in the barrier region (b), or transversal momentum suppression (c) can be used as such a clock.

LETTER

doi:10.1038/nature11025

Resolving the time when an electron exits a tunnelling barrier

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The tunnelling of a particle through a barrier is one of the most fundamental and ubiquitous quantum processes. When induced by an intense laser field, electron tunnelling from atoms and molecules initiates a broad range of phenomena such as the generation of attosecond pulses¹, laser-induced electron diffraction^{2,3} and holography^{2,4}. These processes evolve on the attosecond timescale (1 attosecond = 1 as = 10⁻¹⁸ seconds) and are well suited to the investigation of a general issue much debated since the early days of quantum mechanics⁵⁻⁷—the link between the tunnelling of an electron through a barrier and its dynamics outside the barrier.

Previous experiments have measured tunnelling rates with attosecond time resolution⁸ and tunnelling delay times⁹. Here we study **laser-induced tunnelling** by using a weak probe field to steer the tunnelled electron in the lateral direction and then monitor the effect on the **attosecond light bursts emitted** when the liberated electron re-encounters the parent ion¹⁰. We show that this approach allows us to measure the time at which the electron exits from the tunnelling barrier. We demonstrate the high sensitivity of the measurement by detecting **subtle delays in ionization times from two orbitals of a carbon dioxide molecule**. Measurement of the tunnelling process is essential for all attosecond experiments where strong-field ionization initiates ultrafast dynamics¹⁰. Our approach provides a general tool for time-

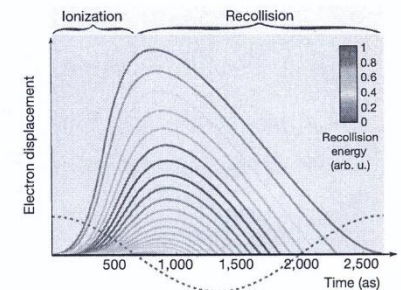


Figure 1 | **Electron trajectories contributing to the recollision process** coloured lines represent the spatio-temporal description of various trajectories, each colour encodes a recolliding energy, increasing from red to blue. The dashed line shows the electric field along the cycle. arb. u., arbitrary unit

Attosecond Ionization and Tunneling Delay Time Measurements in Helium

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H. G. Muller,⁴ M. Büttiker,⁵ U. Keller¹

It is well established that electrons can escape from atoms through tunneling under the influence of strong laser fields, but the timing of the process has been controversial and far too rapid to probe in detail. We used attosecond angular streaking to place an upper limit of 34 attoseconds and an intensity-averaged upper limit of 12 attoseconds on the tunneling delay time in strong field ionization of a helium atom. The ionization field derives from 5.5-femtosecond-long near-infrared laser pulses with peak intensities ranging from 2.3×10^{14} to 3.5×10^{14} watts per square centimeter (corresponding to a Keldysh parameter variation from 1.45 to 1.17, associated with the onset of efficient tunneling). The technique relies on establishing an absolute reference point in the laboratory frame by elliptical polarization of the laser pulse, from which field-induced momentum shifts of the emergent electron can be assigned to a temporal delay on the basis of the known oscillation of the field vector.

We measured a weighted intensity-averaged tunneling delay time of 6.0 as with a standard deviation of the weighted mean of 5.6 as

$$1 \text{ as} \sim 1 \times 10^{-18} \text{ s}$$

Dwell time (tiempo de habitabilidad)

$$\tau_D(E) = \frac{\int_{x_1}^{x_2} |\Psi(x)|^2 dx}{j}, \quad \text{Eq. 1}$$

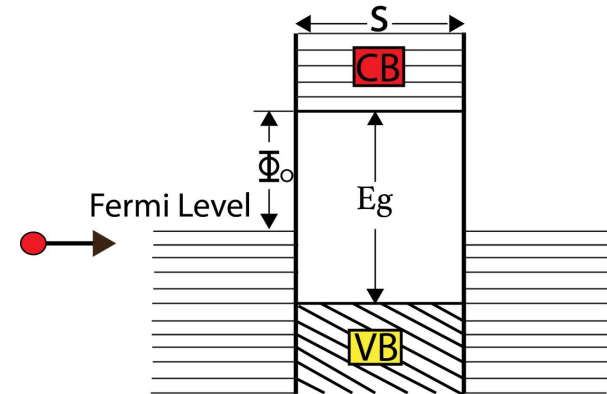
x_1, x_2 , are the classical turning points

momentum



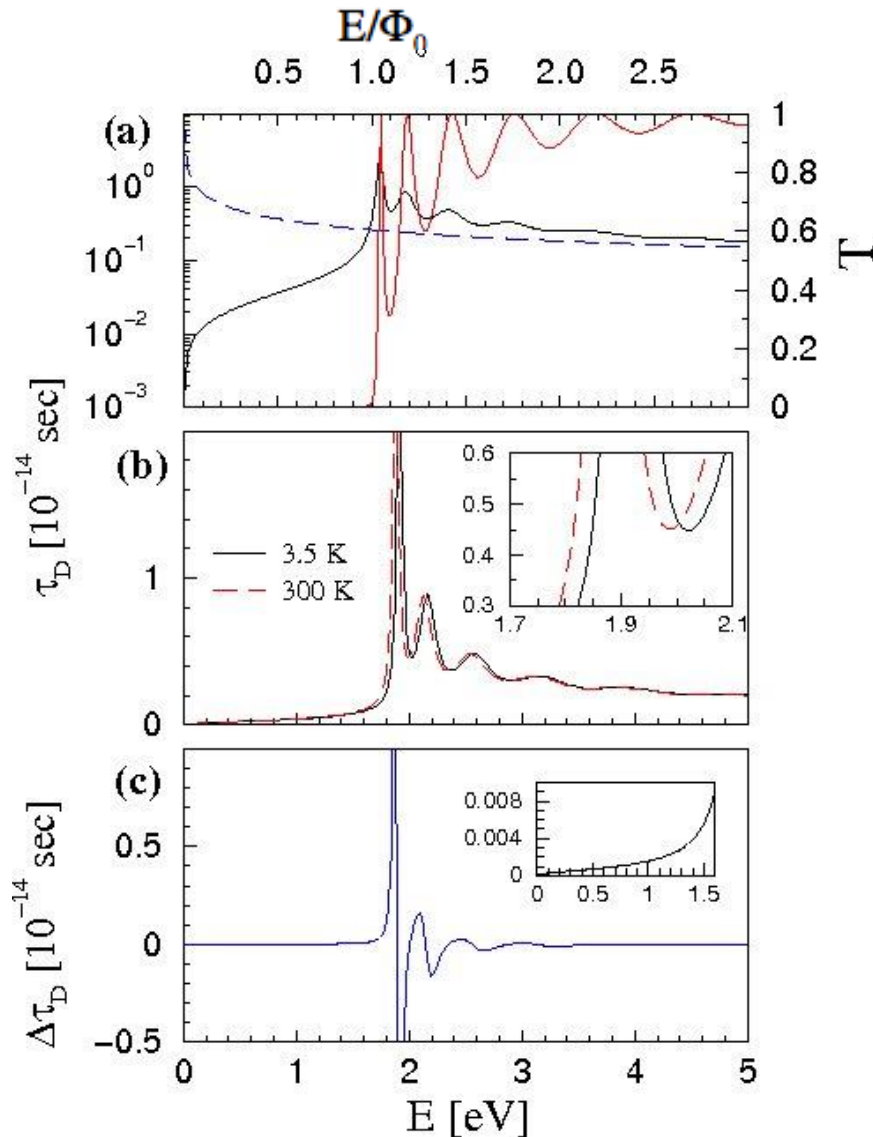
$$j = \hbar k / \mu \quad \leftarrow \text{reduced mass}$$

$$k = \sqrt{2mE} / \hbar$$



Finding the wave function and solving eq. 1 for a rectangular barrier of fixed height and width for $E < \Phi_0$

Finding the wave function and solving eq. 1 for a rectangular barrier :



Average dwell times spent by tunneling electrons within the potential barrier

(a) As a function of the energy divided by the barrier height. The trans-mission coefficient (red line- right scale)

(b) As a function of the energy for two different temperatures.

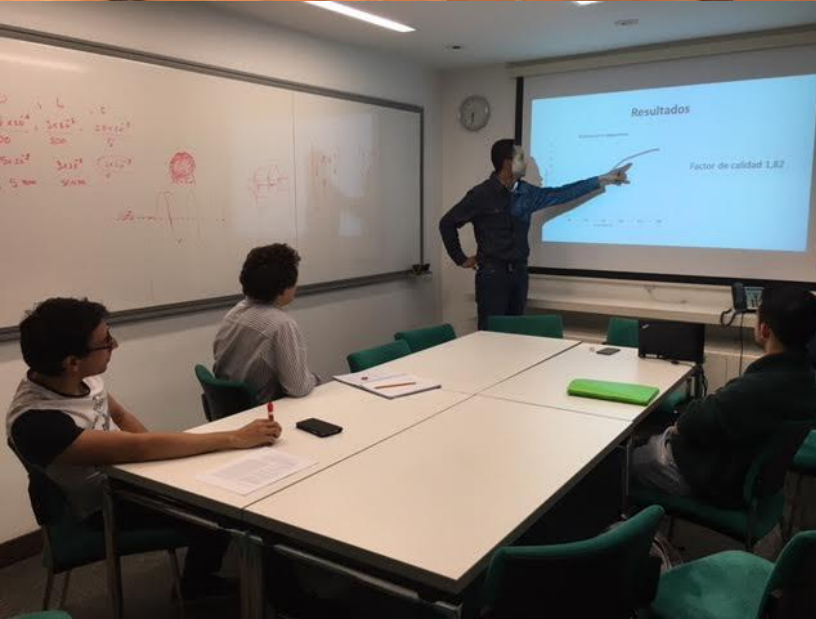
(c) Difference between the dwell time curves at 3.5 and 300 K. Pronounced mostly 300K 3.5K in the resonance regions $\Delta\tau_D = \tau_D(3.5\text{K}) - \tau_D(300\text{K})$

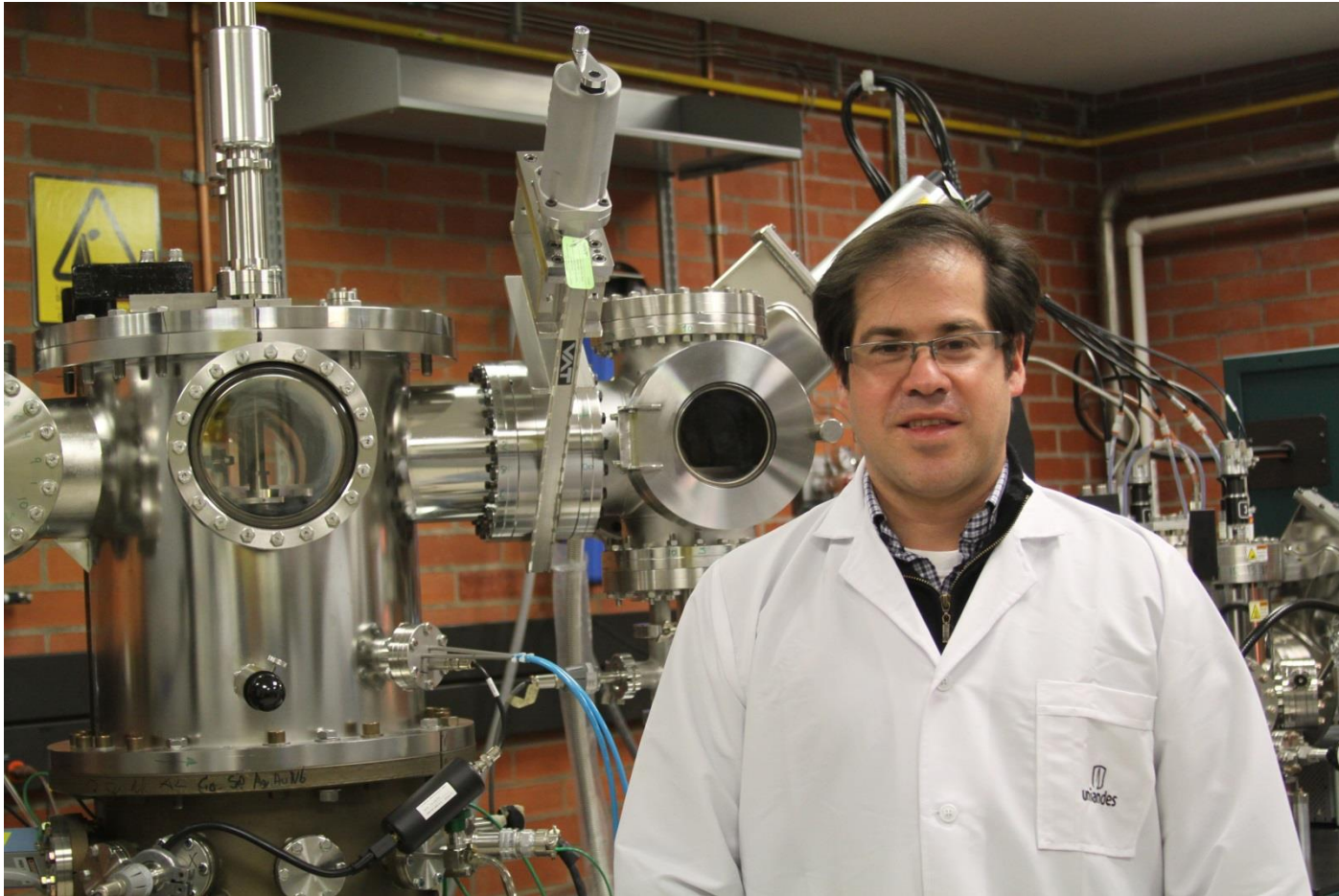
The trans-mission coefficient (red line with scale on right side in (a)).

$$\tau_D = 3.6 \times 10^{-16} \text{ sec at mid barrier energies !}$$

Conclusions

- Tunneling experiments demonstrate a **clear temperature dependence of the barrier height**
- The barrier height temperature dependence is directly linked to energy gap of the semiconductor BUT barrier width $S \approx 20.8 \text{ \AA}$ does not change.
- The phonon average frequency extracted $\omega = 2.24 \times 10^{13} \text{ sec}^{-1}$ is very close to the one obtained from speed of sound experiments, proving this as an accurate technique .
- Tunneling time determined to be $3.6 \times 10^{-16} \text{ sec}$ at mid-barrier energies
- Tunneling experiments in **other** thin semiconducting materials should provide useful information on energy gap and phonon spectrum





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